

Fundamentals of Solid State Physics

Semiconductors - General

Xing Sheng 盛兴

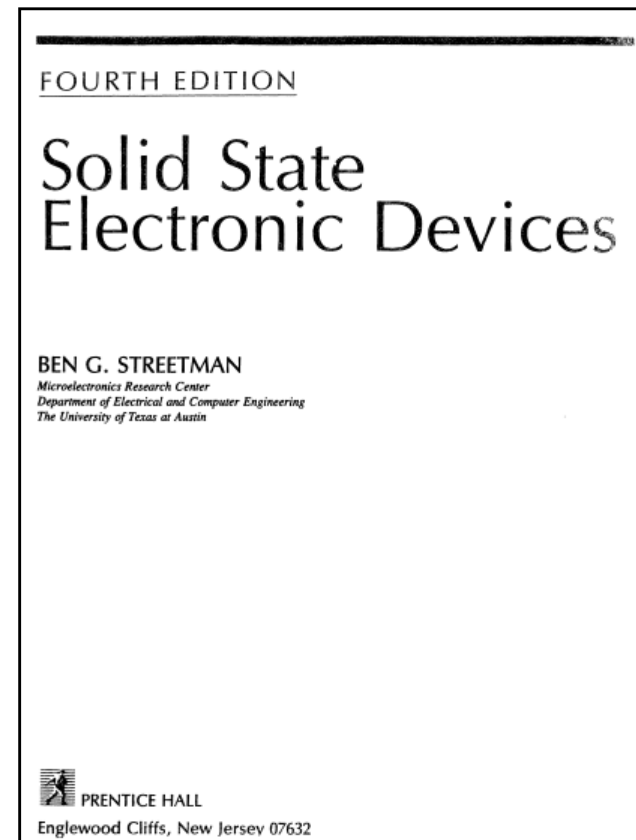
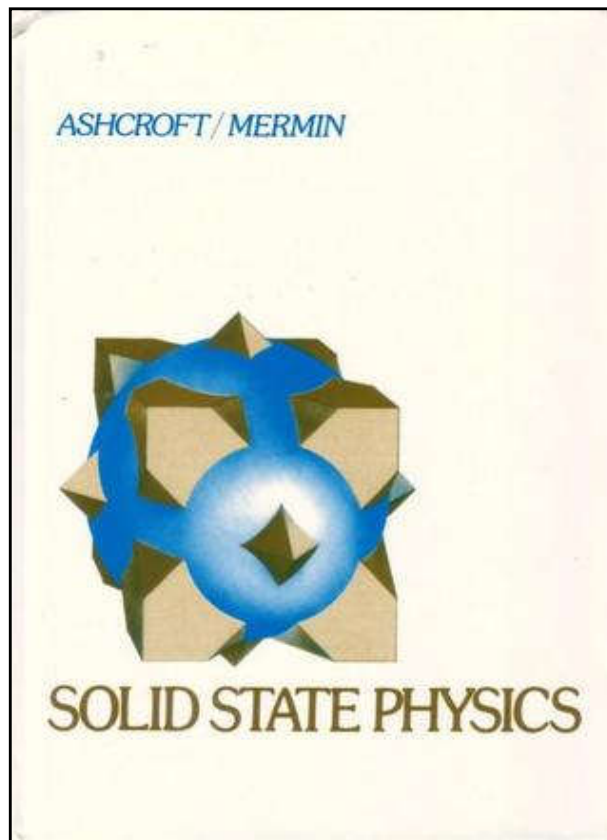


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Further Reading

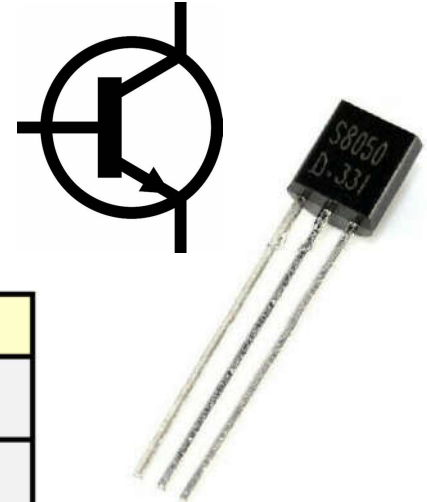
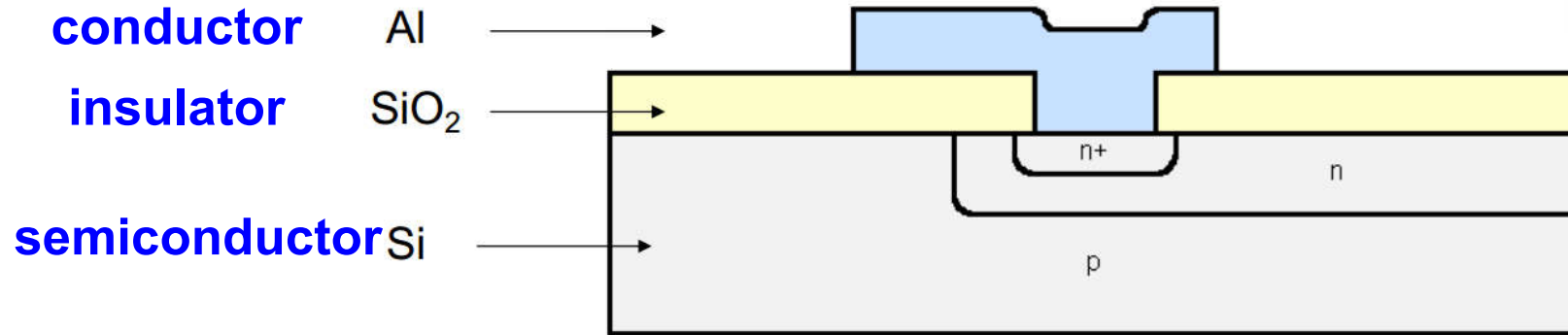
- Ashcroft & Mermin, Chapter 28
- Solid State Electronic Devices by Streetman, Chap.3



Electronic Properties of Materials

CMOS transistor

- Complementary **Metal-Oxide-Semiconductor**



Metal



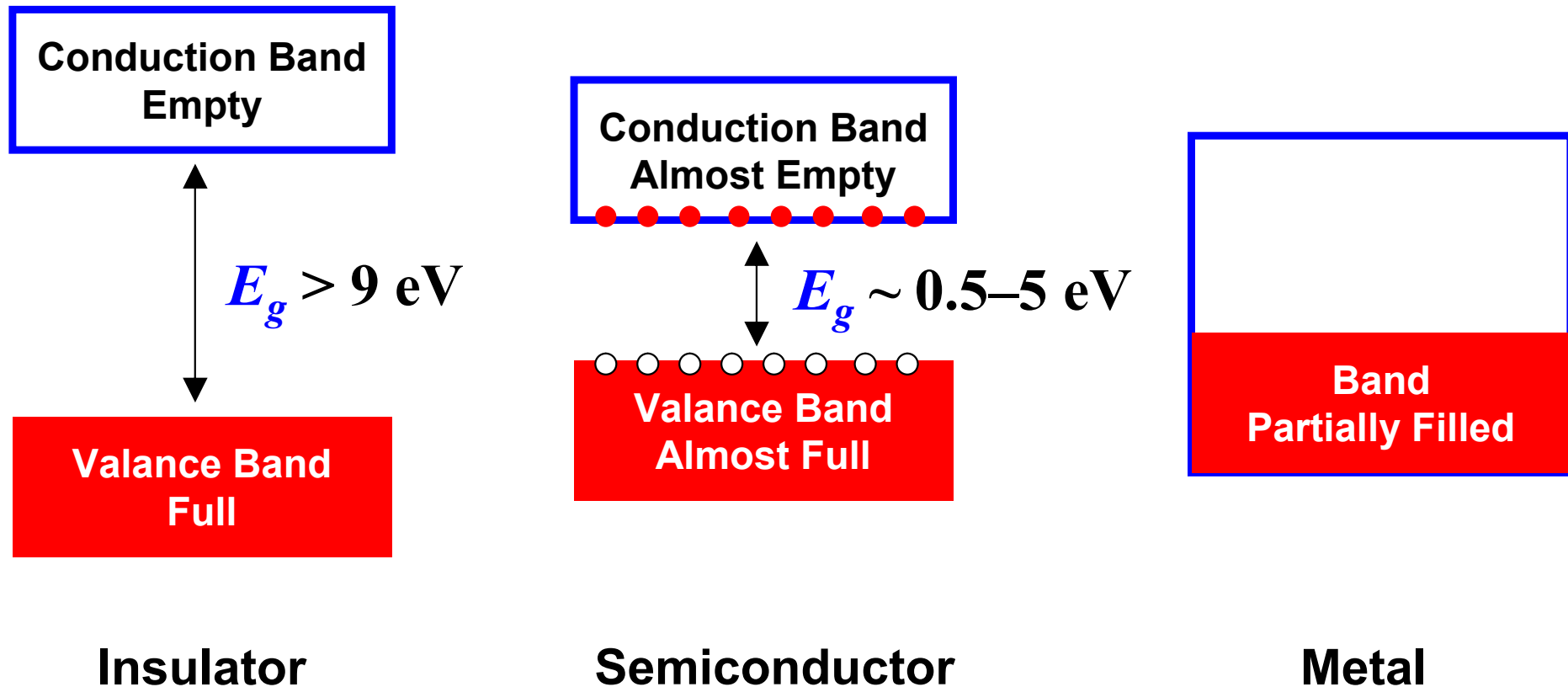
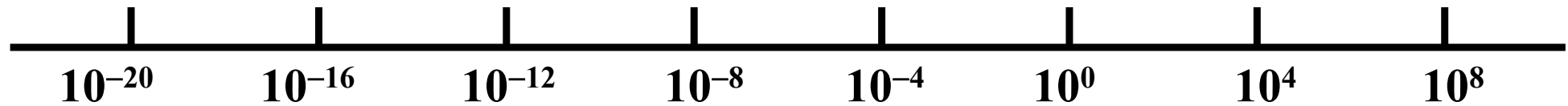
SiO_2



Silicon

Metal, Insulator, Semiconductor

conductivity (S/cm)



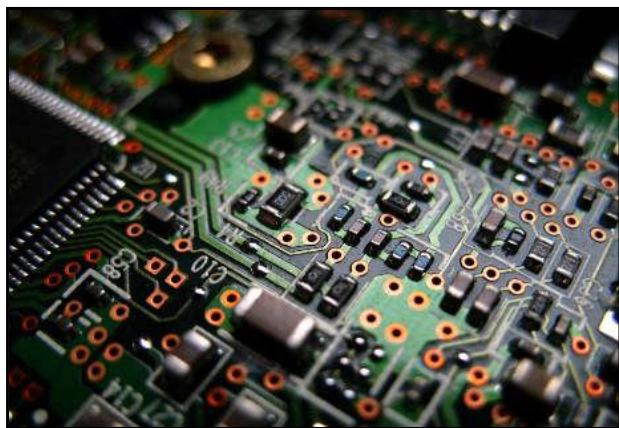
Semiconductors - General Concepts

- Band diagram $E(k)$
- Band gap E_g
- Effective mass m^*
- Holes
- Density of States (DOS) $g(E)$
- Density of Carriers n_c and p_v
 - Mass Action Law

- Intrinsic and Extrinsic

Semiconductors - Applications

semiconductors are the basis of electronics and photonics



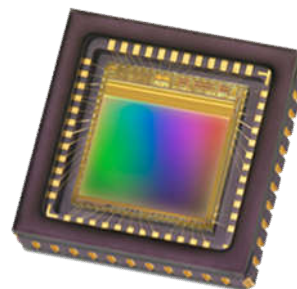
integrated circuits



LEDs



lasers

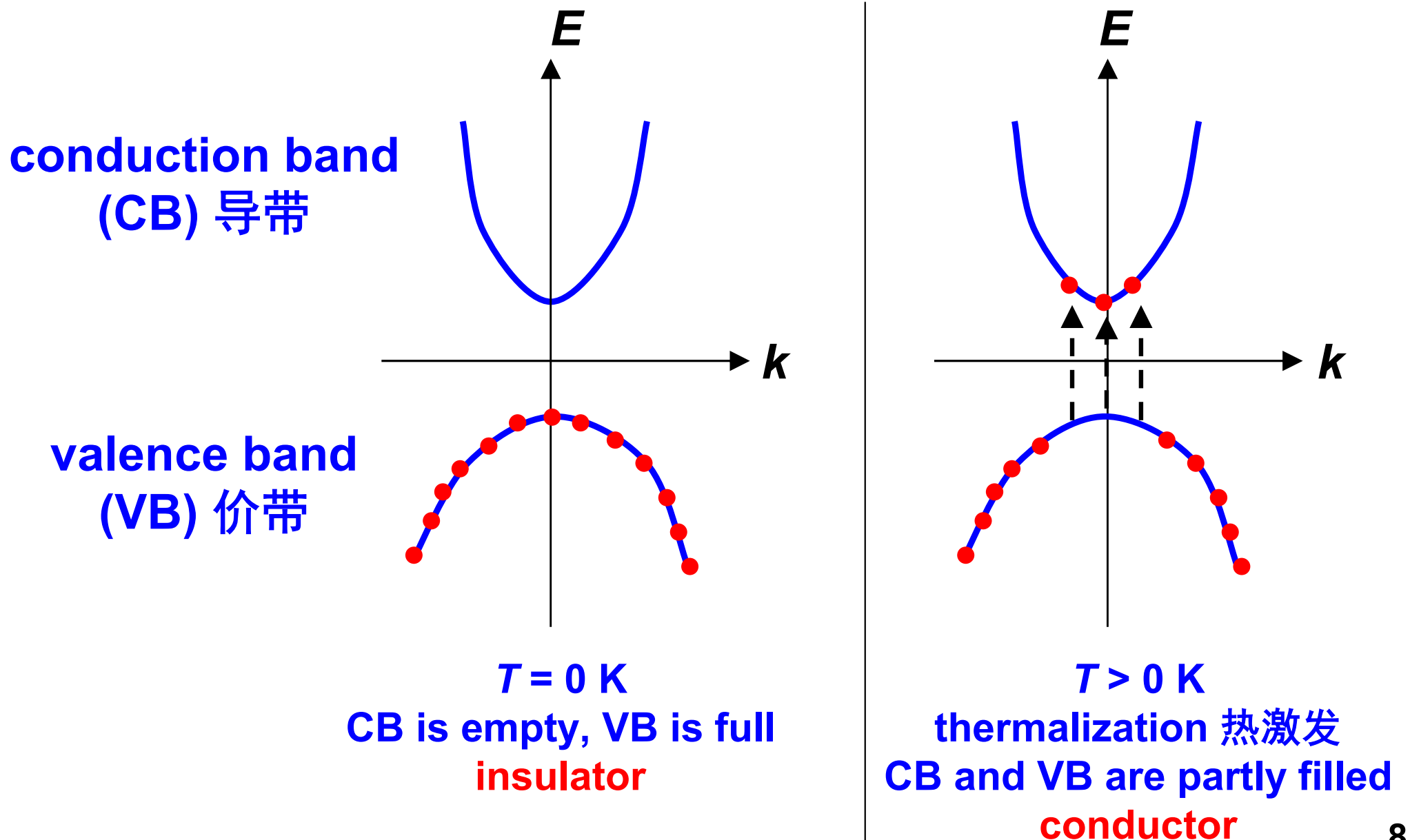


detectors



solar cells

Semiconductor 半导体



Band Structure / Diagram 能带图

Free electrons

energy

$$E(k) = \frac{\hbar^2 k^2}{2m}$$

velocity

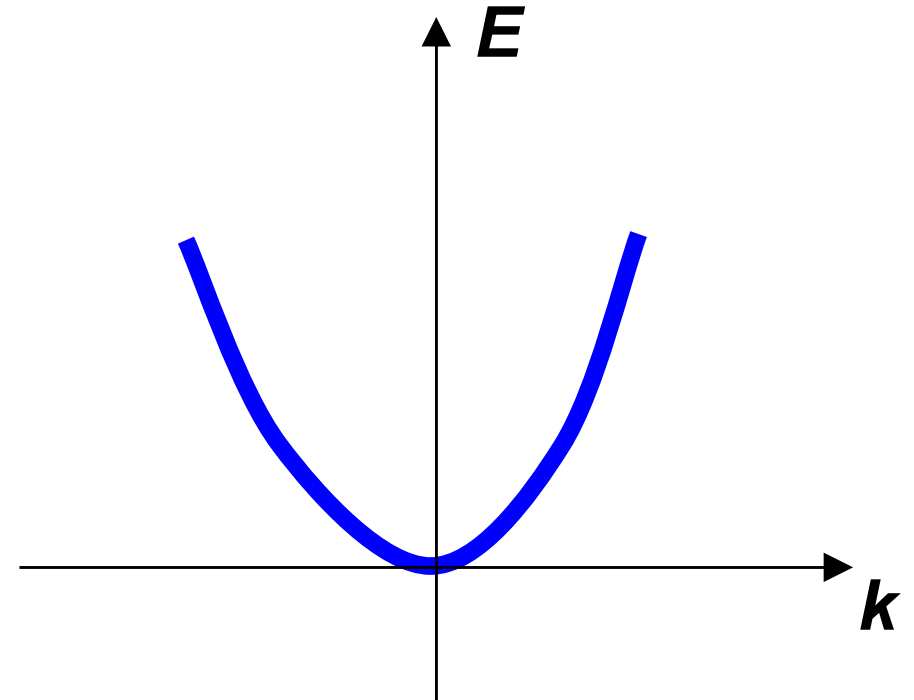
$$v = \frac{\hbar k}{m} = \frac{1}{\hbar} \frac{dE(k)}{dk}$$

momentum

$$p = \hbar k$$

electron mass

$$\frac{1}{m} = \frac{1}{\hbar^2} \frac{d^2 E(k)}{dk^2}$$



**E - k diagram
(energy dispersion curve)**

Band Structure / Diagram 能带图

energy

$$E(k)$$

band gap

$$E_g$$

crystal momentum
(*not* electron momentum)

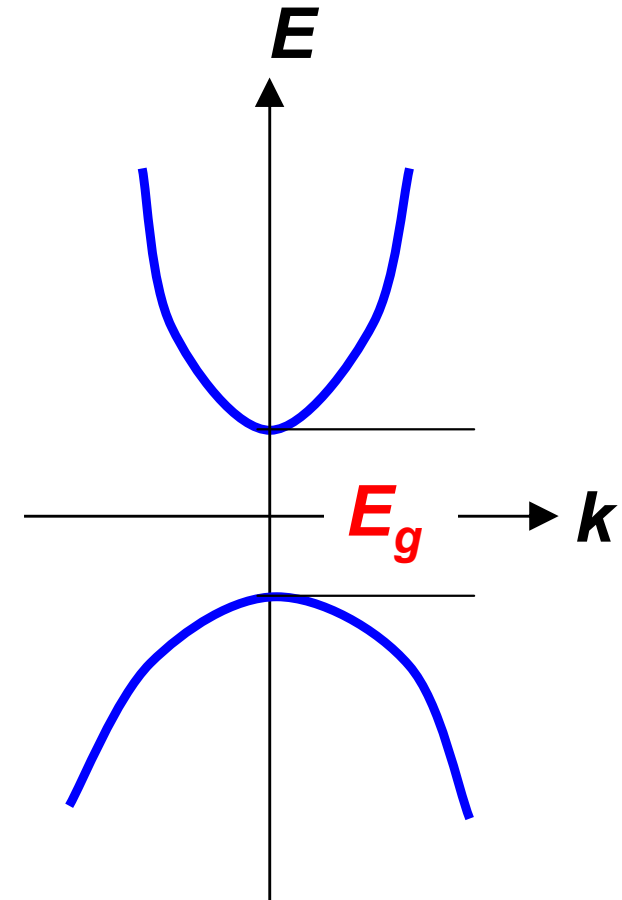
$$\hbar k$$

group velocity

$$v_g = \frac{1}{\hbar} \frac{dE(k)}{dk}$$

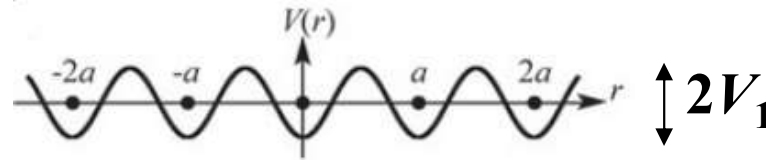
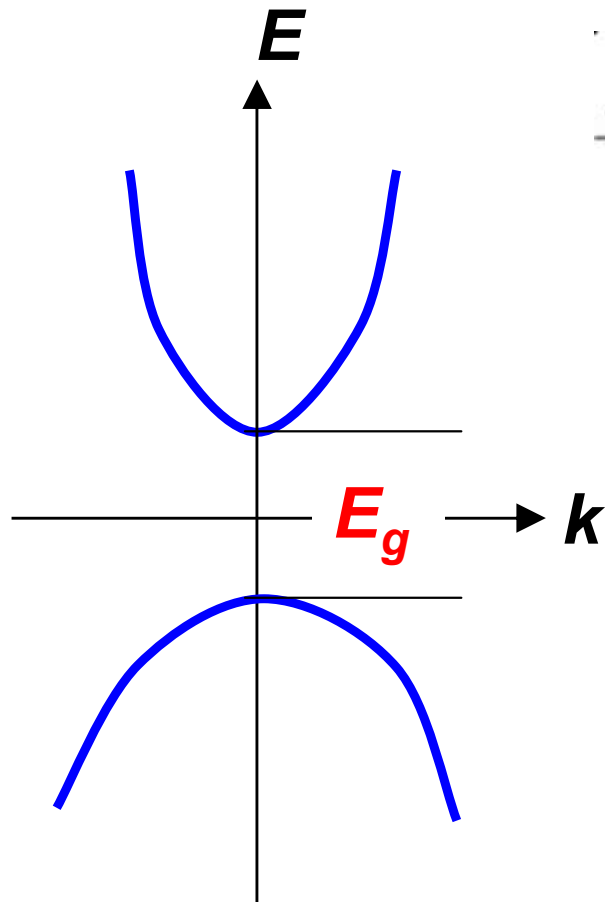
or

$$\mathbf{v} = \frac{1}{\hbar} \nabla_{\mathbf{k}} E(\mathbf{k})$$



E-k diagram
(energy dispersion curve)

Band Gap E_g



$$E_g = 2V_1$$

the nearly free
electron model

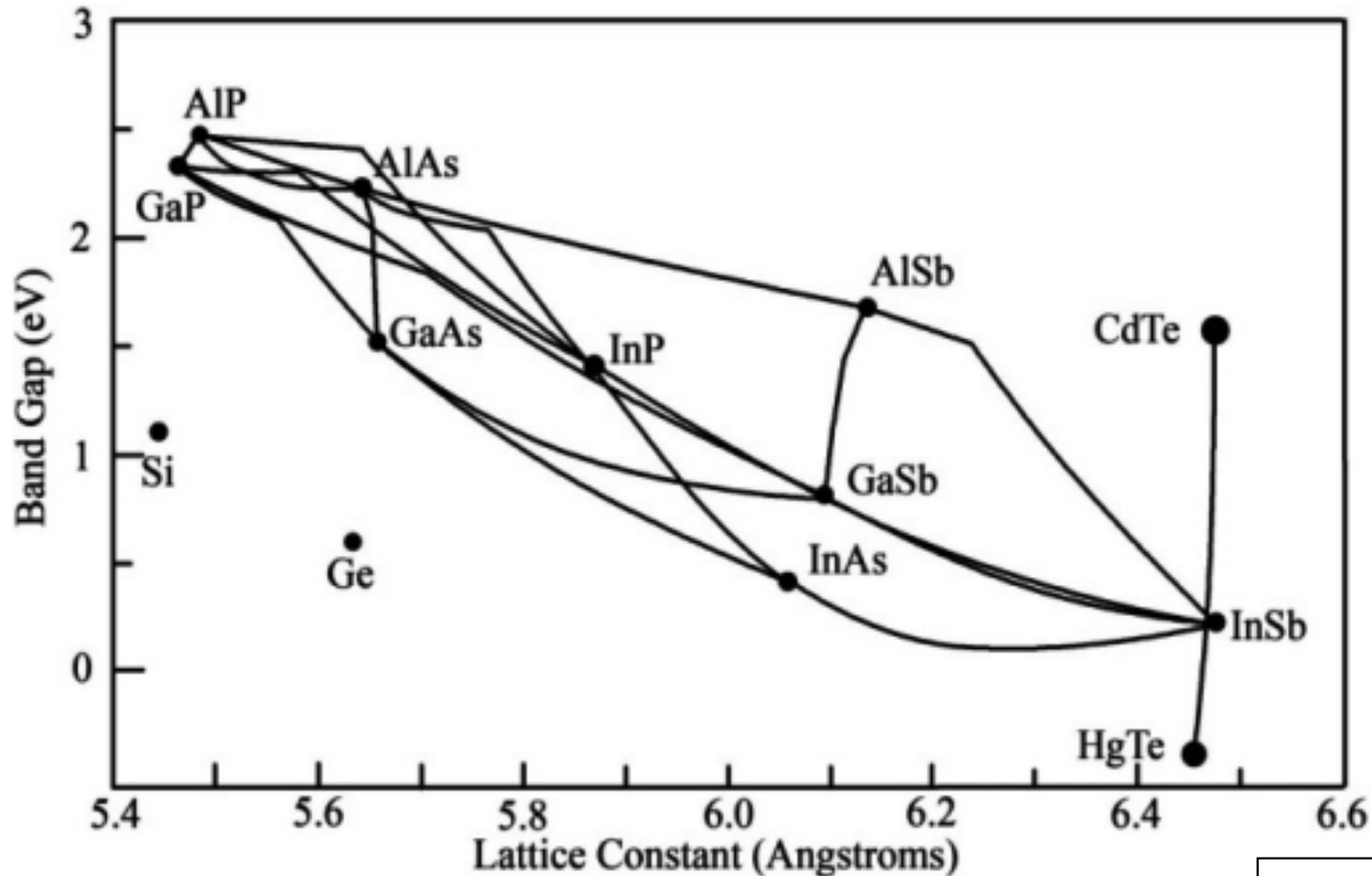
		III	IV	V		2
	5	6	7	8	9	10
	B	C	N	O	F	Ne
	13	14	15	16	17	18
	Al	Si	P	S	Cl	Ar
	31	32	33	34	35	36
	Ga	Ge	As	Se	Br	Kr
	49	50	51	52	53	54
	In	Sn	Sb	Te	I	Xe
	81	82	83	84	85	86
	Tl	Pb	Bi	Po	At	Rn

at $T = 300 \text{ K}$

	a (Å)	E_g (eV)
C (diamond)	3.57	5.5
Si	5.43	1.1
Ge	5.66	0.66
α -Sn	6.49	0.08

Q: Why?

Band Gap E_g



	III	IV	V			2
	5	6	7	8	9	10
	B	C	N	O	F	Ne
	13	14	15	16	17	18
	Al	Si	P	S	Cl	Ar
	31	32	33	34	35	36
	Ga	Ge	As	Se	Br	Kr
	49	50	51	52	53	54
	In	Sn	Sb	Te	I	Xe
	81	82	83	84	85	86
	Tl	Pb	Bi	Po	At	Rn

Si > Ge

AlAs > GaAs > InAs

GaP > GaAs > GaSb

larger atoms
-> smaller V_1
-> smaller E_g

Band Gap E_g

	E_g (eV)
Si	1.1
AIP	2.5
MgS	4.0
NaCl	8.5

	E_g (eV)
Ge	0.7
GaAs	1.4
ZnSe	3.5
KBr	7.5

lements

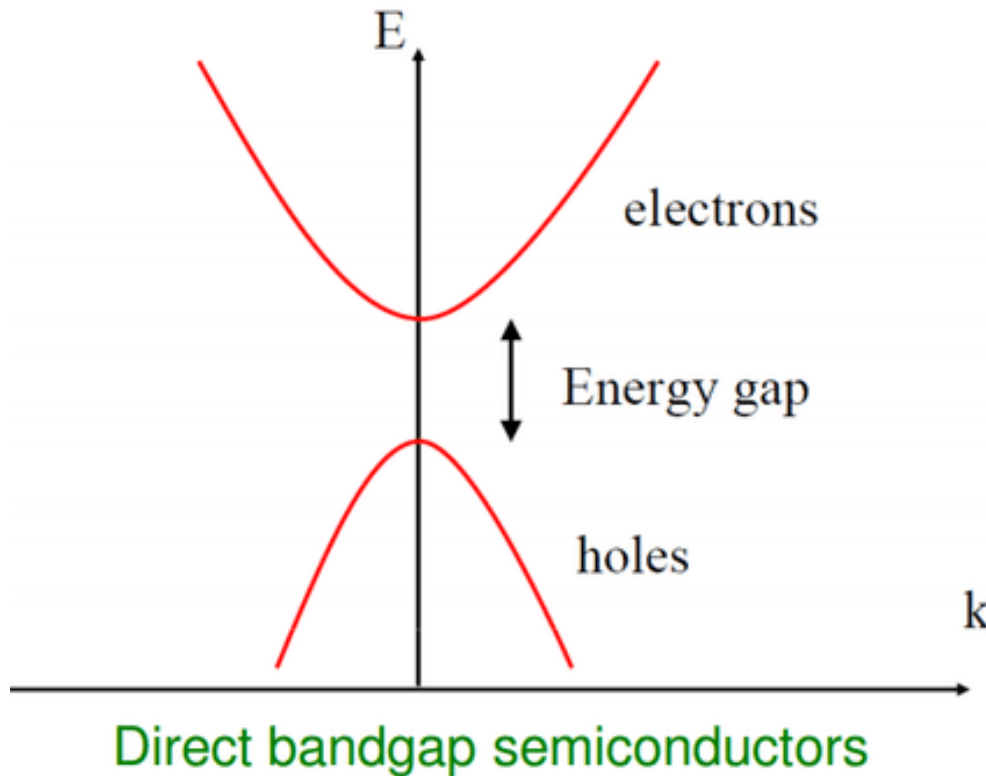
	13 IIIA 3A	14 IVA 4A	15 VA 5A	16 VIA 6A	17 VIIA 7A
5	B Boron 10.811	C Carbon 12.011	N Nitrogen 14.007	O Oxygen 15.999	F Fluorine 18.998
11	Na Sodium 22.990	Mg Magnesium 24.305	Al Aluminum 26.982	Si Silicon 28.086	P Phosphorus 30.974
16	K Potassium 39.098	Zn Zinc 65.38	Ga Gallium 69.723	Ge Germanium 72.631	As Arsenic 74.922
21		Cd Cadmium 112.411	In Indium 114.818	Sn Tin 118.711	Sb Antimony 121.760
26				Te Tellurium 127.6	I Iodine 126.904

Si < AIP < MgS < NaCl

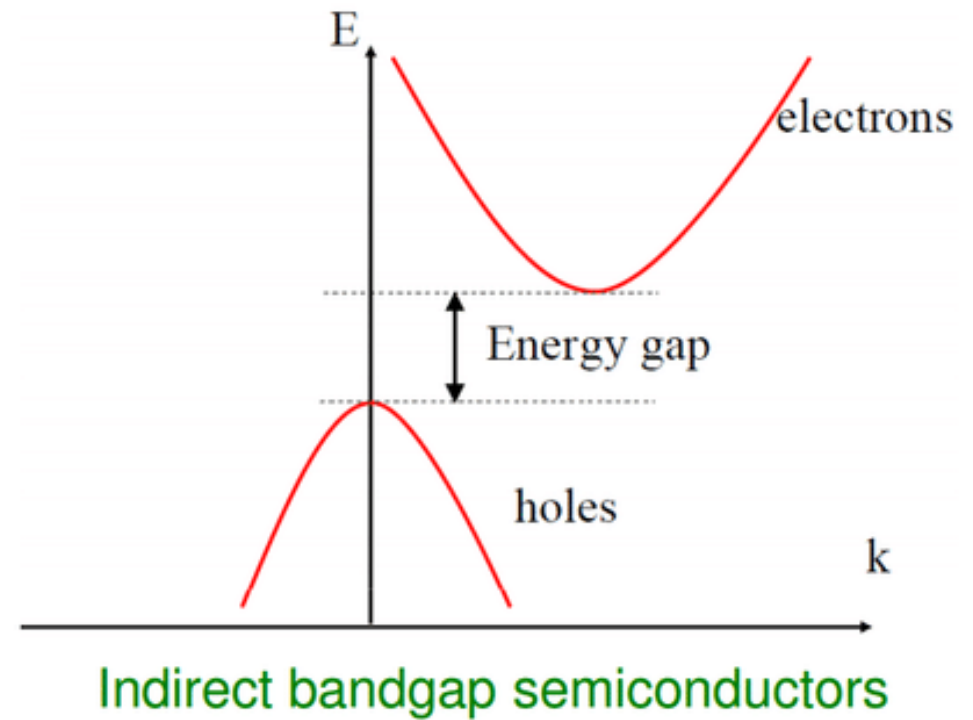
Ge < GaAs < ZnSe < KBr

more polarity
-> larger V_1
-> larger E_g

Direct and Indirect Gaps

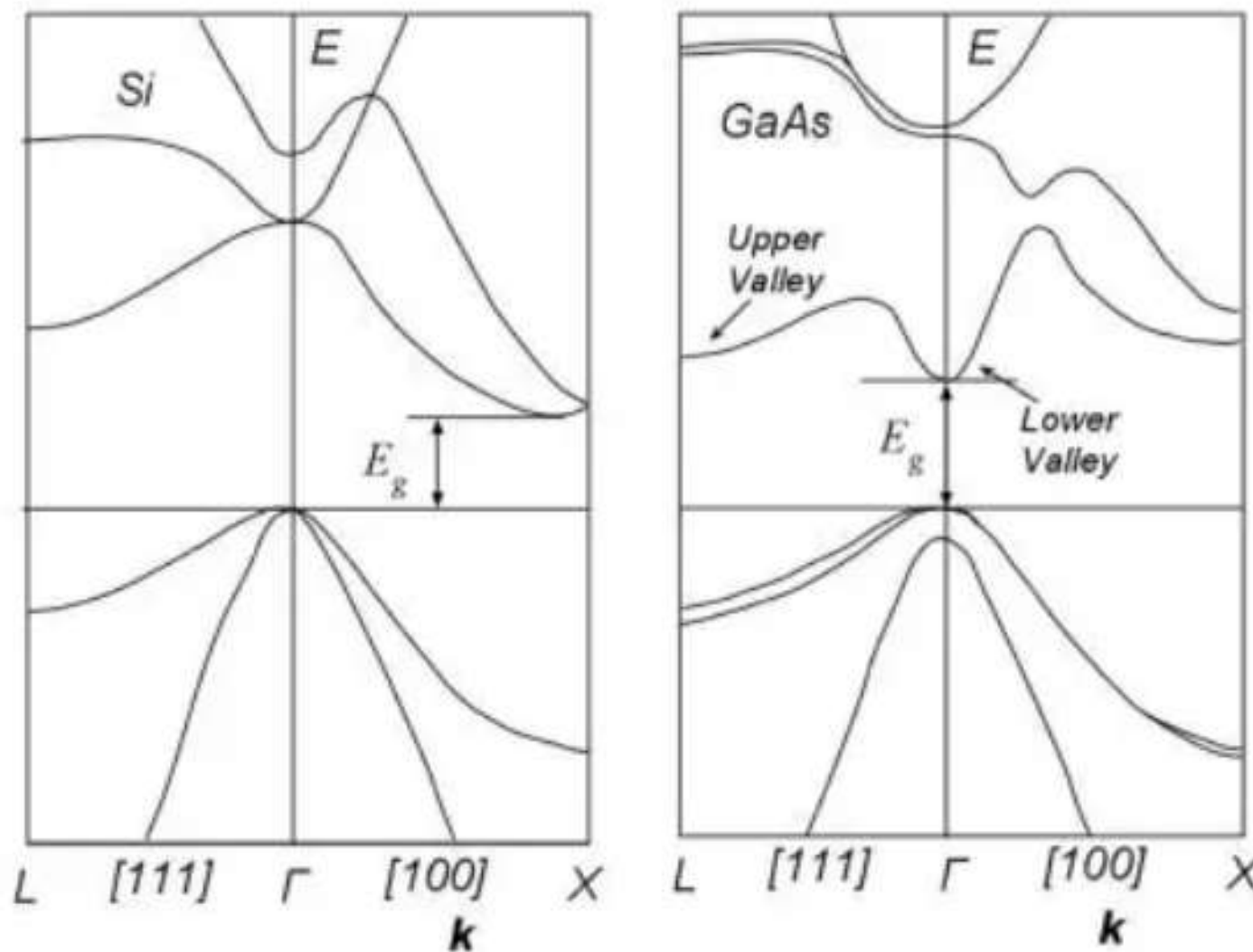


直接帶隙



间接帶隙

Direct and Indirect Gaps



Silicon - indirect

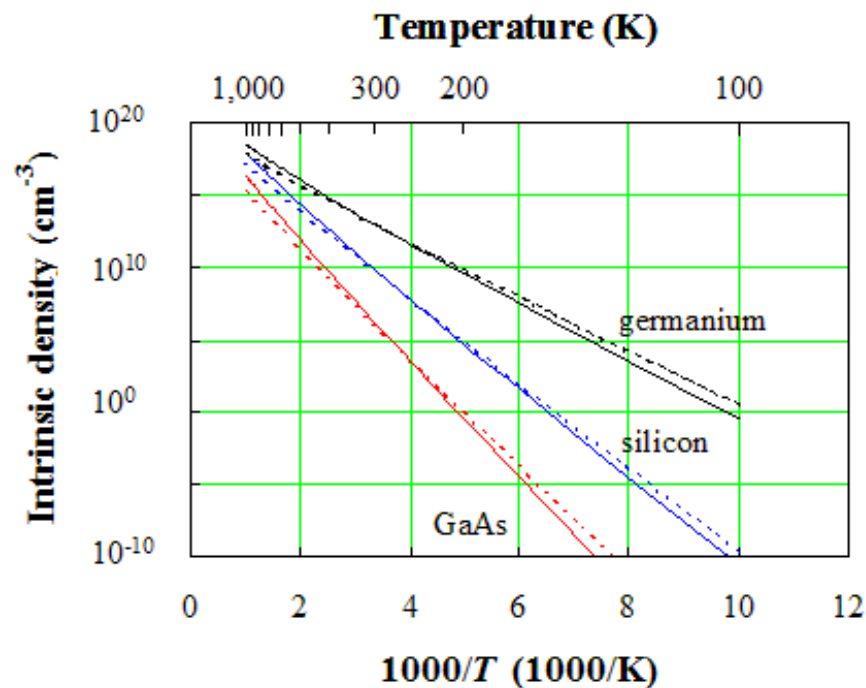
GaAs - direct

Measurement of Band Gaps

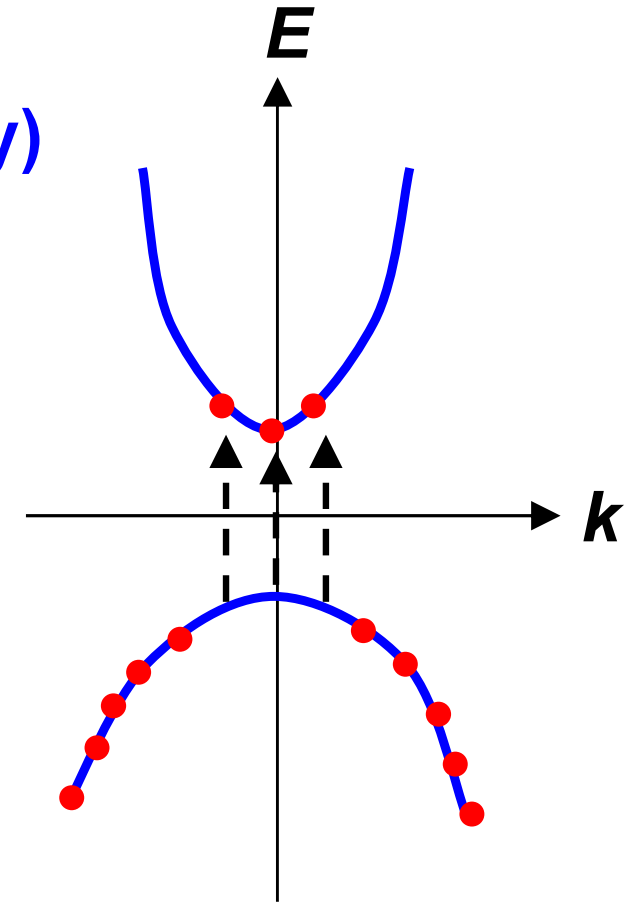
temperature dependence
of carrier concentration (or conductivity)

$$n_i \propto T^{3/2} \cdot e^{-E_g/2k_B T}$$

$$\ln n_i \sim -\frac{E_g}{2k_B T}$$



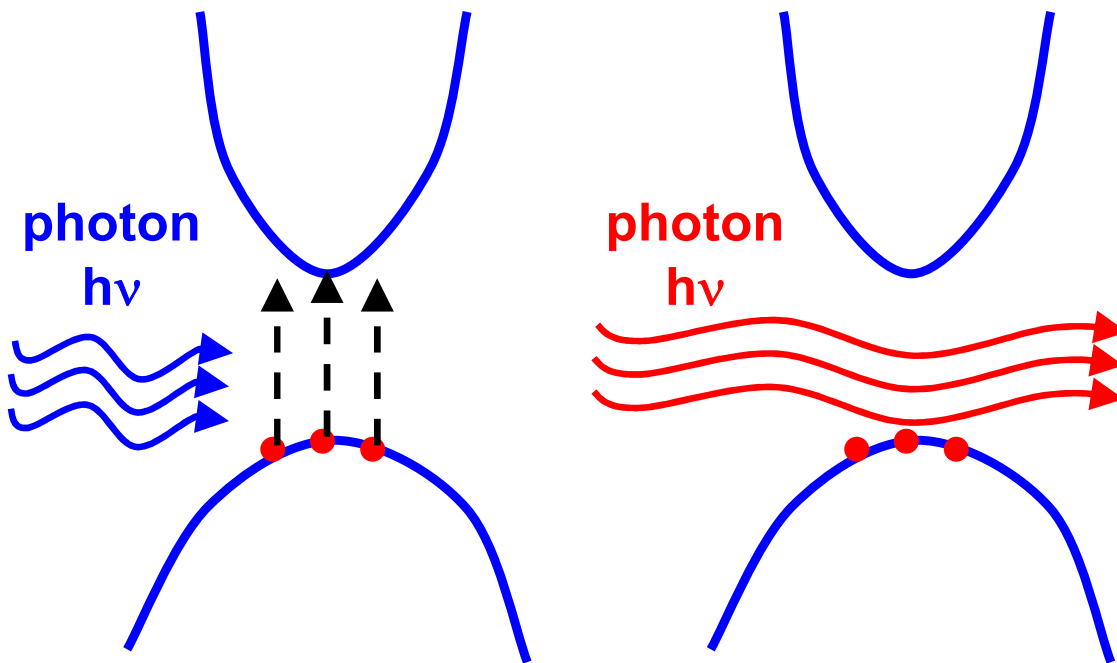
© Bart Van Zeghbroeck 2007



$T > 0 \text{ K}$
thermalization 热激发
CB and VB are partly filled
conductor

Measurement of Band Gaps

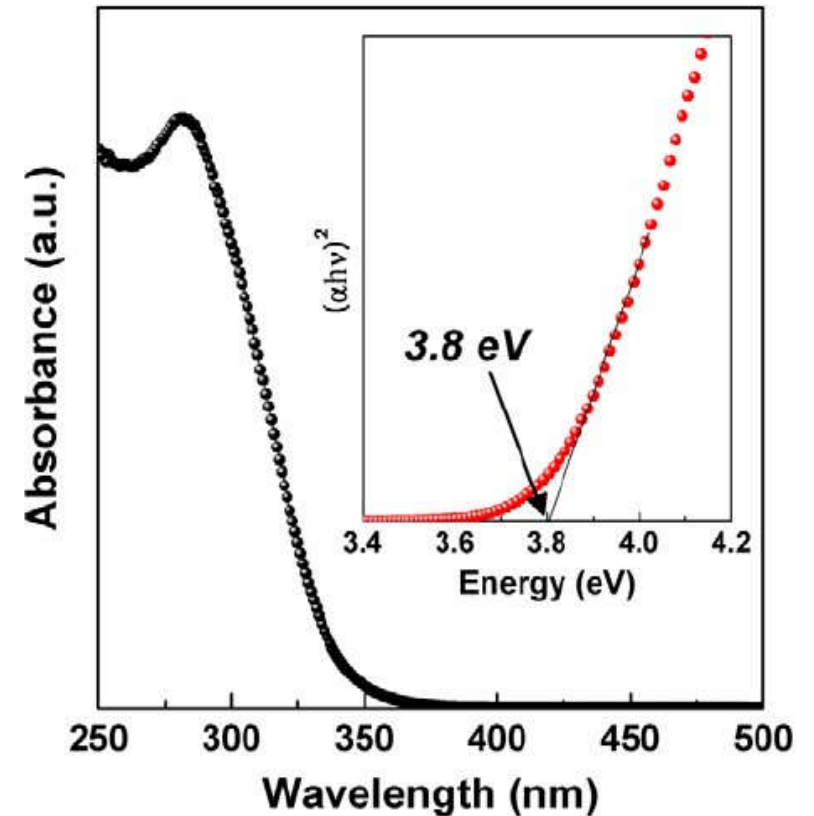
wavelength dependent
optical absorption



$h\nu > E_g$ \rightarrow light absorption

$h\nu < E_g$ \rightarrow light transmission

Example:
 Zn_2SnO_4 nanoparticles



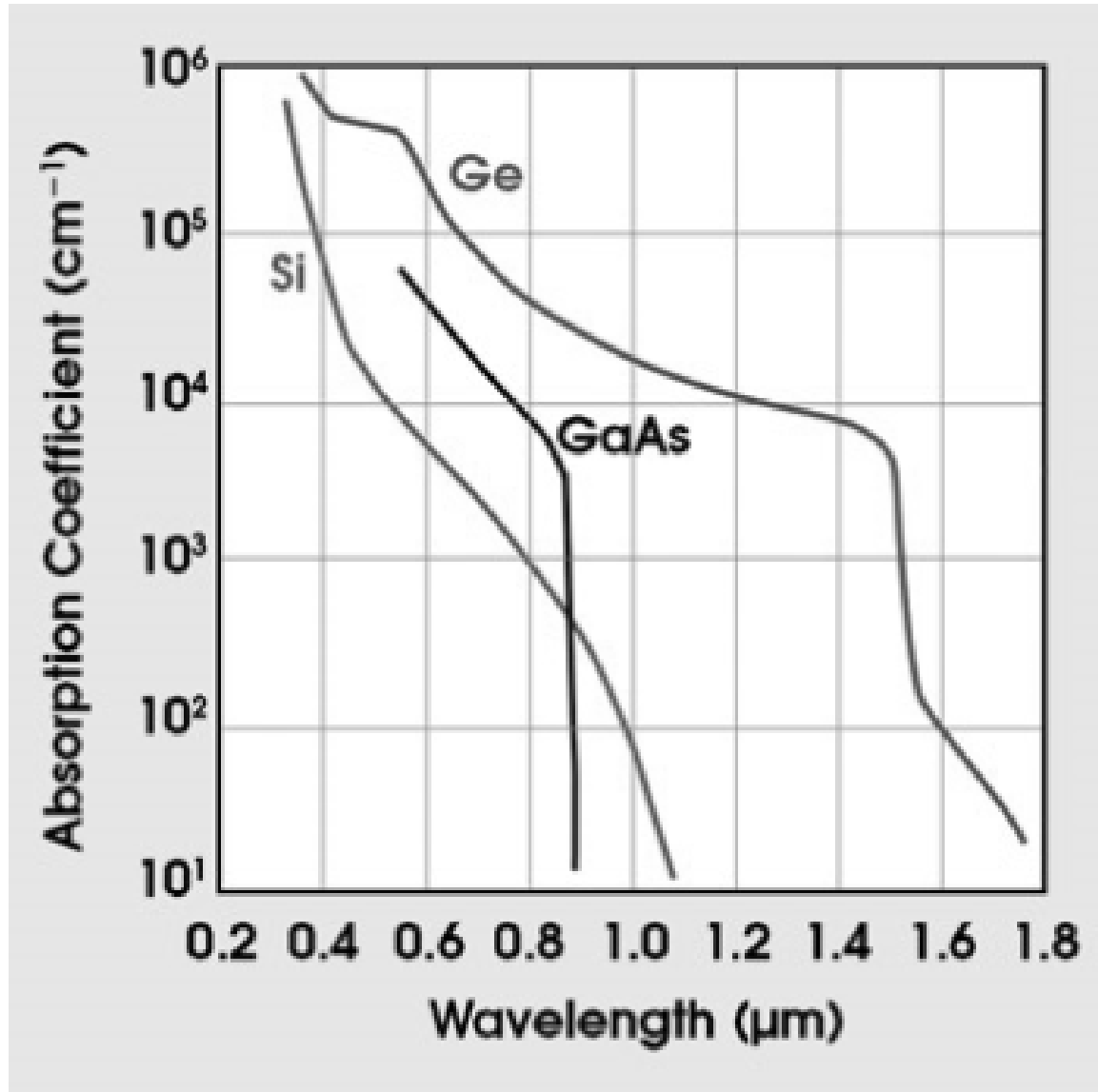
D. Kim, *et al*, *Nanoscale* 4, 557 (2011)

Measurement of Band Gaps

$$E_g = \frac{hc}{\lambda_g} \rightarrow$$

$$E(\text{eV}) = \frac{1240}{\lambda(\text{nm})}$$

	E_g (eV)
Si	1.1
Ge	0.66
GaAs	1.43



Effective Mass 有效质量

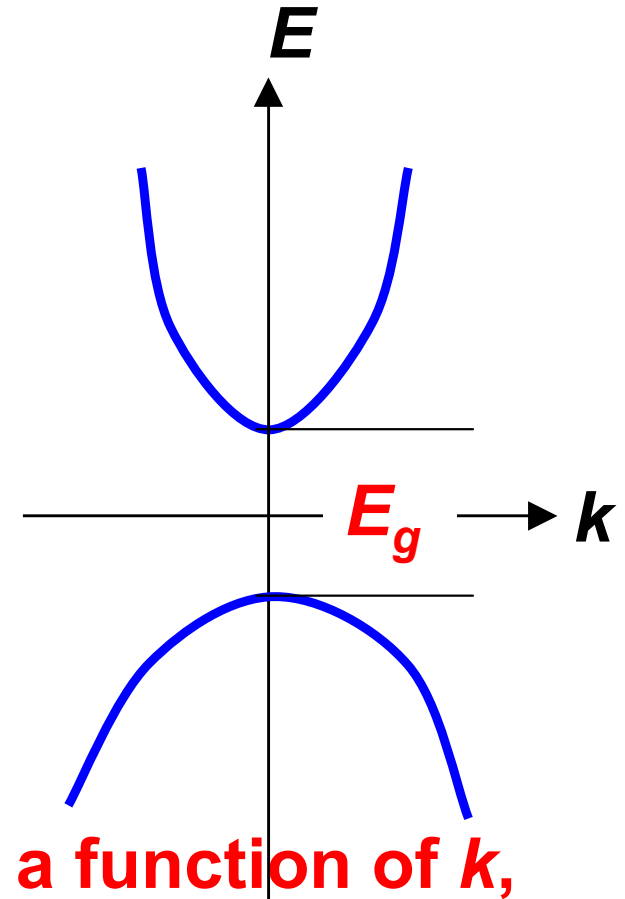
effective mass

$$\frac{1}{m^*} = \frac{1}{\hbar^2} \frac{d^2 E(k)}{dk^2}$$

*The mass that an electron "seems" to have in a solid.
It has nothing to do with the free electron mass m_0*

For 3D solids, a tensor form

$$\frac{1}{\mathbf{M}^*} = \frac{1}{\hbar^2} \begin{pmatrix} \frac{\partial^2 E}{\partial k_x^2} & \frac{\partial^2 E}{\partial k_x \partial k_y} & \frac{\partial^2 E}{\partial k_x \partial k_z} \\ \frac{\partial^2 E}{\partial k_y \partial k_x} & \frac{\partial^2 E}{\partial k_y^2} & \frac{\partial^2 E}{\partial k_y \partial k_z} \\ \frac{\partial^2 E}{\partial k_z \partial k_x} & \frac{\partial^2 E}{\partial k_z \partial k_y} & \frac{\partial^2 E}{\partial k_z^2} \end{pmatrix}$$



**m^* is a function of k ,
can be smaller or
larger than m_0 , even
can be negative**

$$m_0 = 9.11 \cdot 10^{-31} \text{ kg}$$

Effective Mass 有效质量

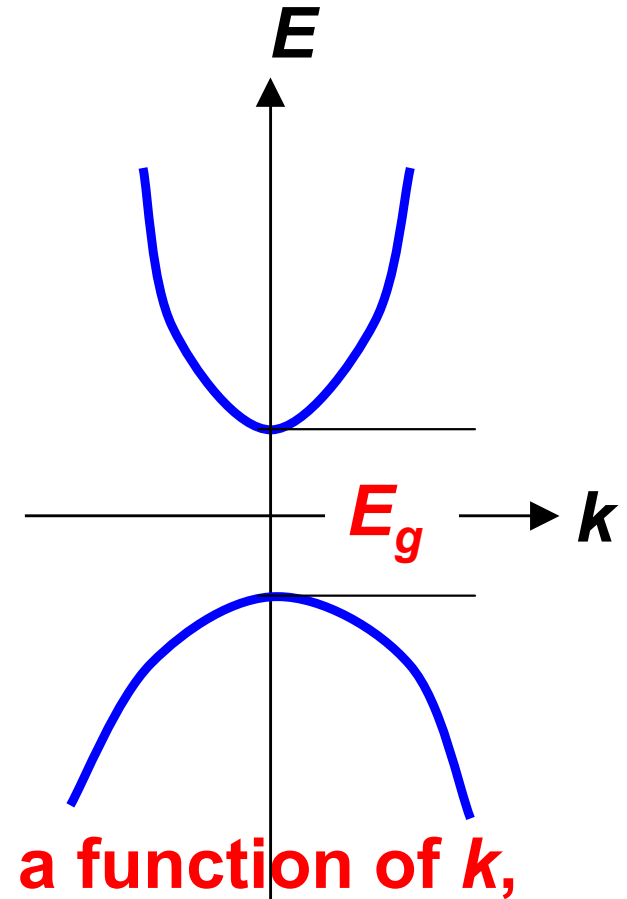
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For 3D solids, a tensor form

$$\frac{1}{\mathbf{M}_{ij}^*} = \frac{1}{\hbar^2} \frac{\partial^2 E}{\partial k_i \partial k_j}$$



**m^* is a function of k ,
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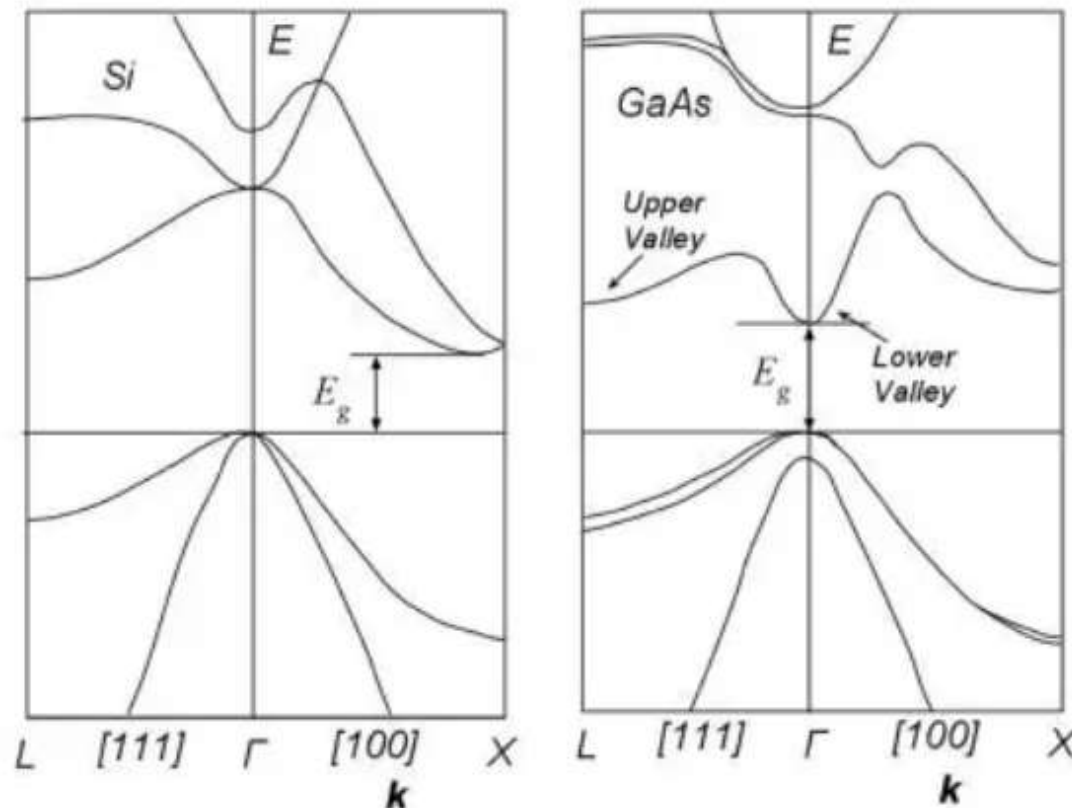
$$m_0 = 9.11 \cdot 10^{-31} \text{ kg}$$

Effective Mass 有效质量

The actual effective mass is a tensor, depending on the location (k_x, k_y, k_z)

$$\frac{1}{\mathbf{M}_{ij}^*} = \frac{1}{\hbar^2} \frac{\partial^2 E}{\partial k_i \partial k_j}$$

Approximation is taken for different calculations.



Effective Mass 有效质量

The actual effective mass is a tensor, depending on the location (k_x, k_y, k_z)

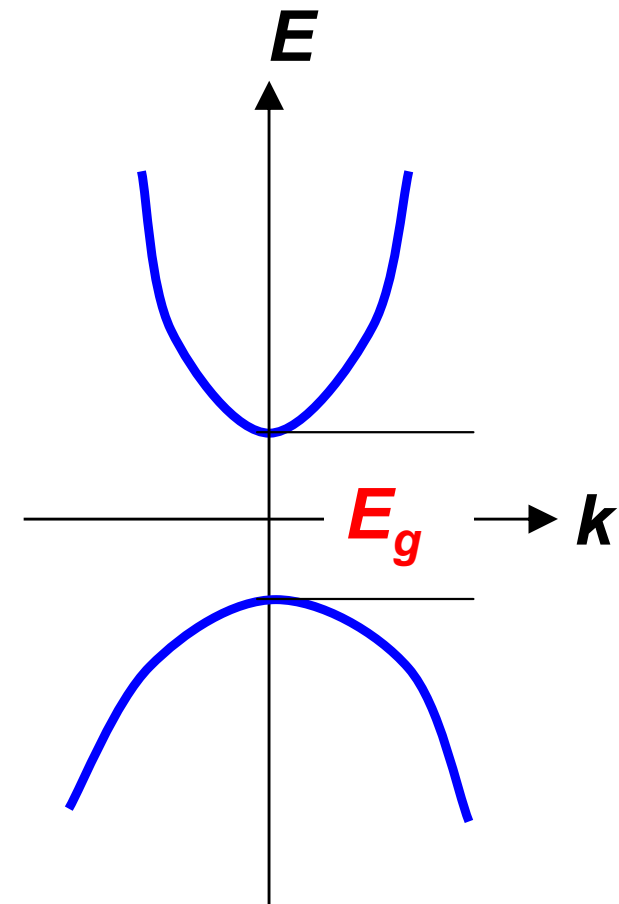
$$\frac{1}{\mathbf{M}_{ij}^*} = \frac{1}{\hbar^2} \frac{\partial^2 E}{\partial k_i \partial k_j}$$

mobility

$$\mu = \frac{v}{E} = e \frac{\tau}{m^*}$$

conductivity

$$\sigma = ne\mu = ne^2 \frac{\tau}{m^*}$$



Effective Mass 有效质量

The actual effective mass is a tensor, depending on the location (k_x, k_y, k_z)

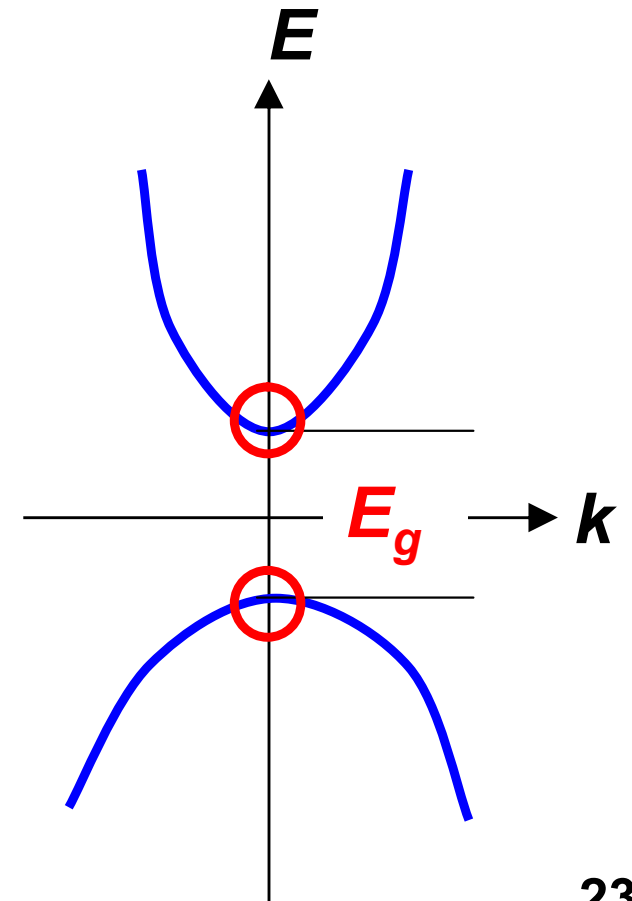
$$\frac{1}{\mathbf{M}_{ij}^*} = \frac{1}{\hbar^2} \frac{\partial^2 E}{\partial k_i \partial k_j}$$

close to band minimum
parabolic approximation

$$E(k) \approx E_0 + \frac{\hbar^2}{2m^*} (k - k_0)^2$$

3D DOS

$$g(E) = \frac{dn}{dE} = \frac{1}{2\pi^2} \left(\frac{2m^*}{\hbar^2} \right)^{3/2} (E - E_0)^{1/2}$$



Effective Mass 有效质量

The actual effective mass is a tensor, depending on the location (k_x, k_y, k_z)

$$\frac{1}{\mathbf{M}_{ij}^*} = \frac{1}{\hbar^2} \frac{\partial^2 E}{\partial k_i \partial k_j}$$

Approximation is taken for different calculations:

- Density of states calculations

$$g(E) = \frac{dn}{dE} = \frac{1}{2\pi^2} \left(\frac{2m^*}{\hbar^2} \right)^{3/2} (E - E_0)^{1/2}$$

- Conductivity / mobility calculations

$$\sigma = ne\mu = ne^2 \frac{\tau}{m^*}$$

Effective Mass 有效质量

The actual effective mass is a tensor, depending on the location (k_x, k_y, k_z)

$$\frac{1}{\mathbf{M}_{ij}^*} = \frac{1}{\hbar^2} \frac{\partial^2 E}{\partial k_i \partial k_j}$$

Approximation is taken for different calculations.

	Symbol	Germanium	Silicon	Gallium Arsenide
Smallest energy bandgap at 300 K	E_g (eV)	0.66	1.12	1.424
Effective mass for density of states calculations				
Electrons	$m_{e^*,dos}/m_0$	0.56	1.08	0.067
Holes	$m_{h^*,dos}/m_0$	0.29	0.57/0.81 ¹	0.47
Effective mass for conductivity calculations				
Electrons	$m_{e^*,cond}/m_0$	0.12	0.26	0.067
Holes	$m_{h^*,cond}/m_0$	0.21	0.36/0.386 ¹	0.34
Free electron mass	m_0 (kg)	9.11 x 10 ⁻³¹		

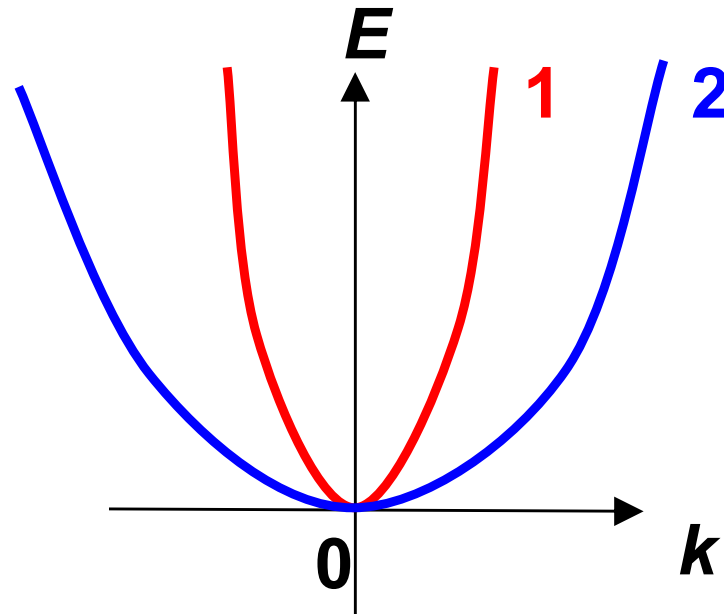
Table 2.3.4 Effective masses for both density of states and conductivity calculations.

Effective Mass 有效质量

effective mass

$$\frac{1}{m^*} = \frac{1}{\hbar^2} \frac{d^2 E(k)}{dk^2}$$

inverse curvature of the parabolic curve



Q: $m_1 > m_2$
or $m_1 < m_2$?

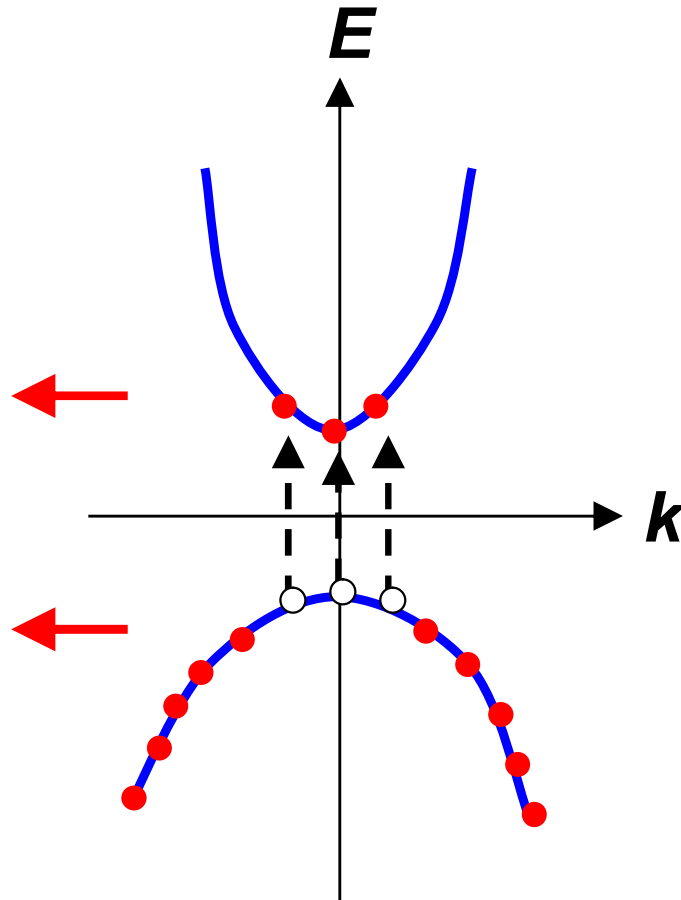
Effective Mass 有效质量

effective mass

$$\frac{1}{m^*} = \frac{1}{\hbar^2} \frac{d^2 E(k)}{dk^2}$$

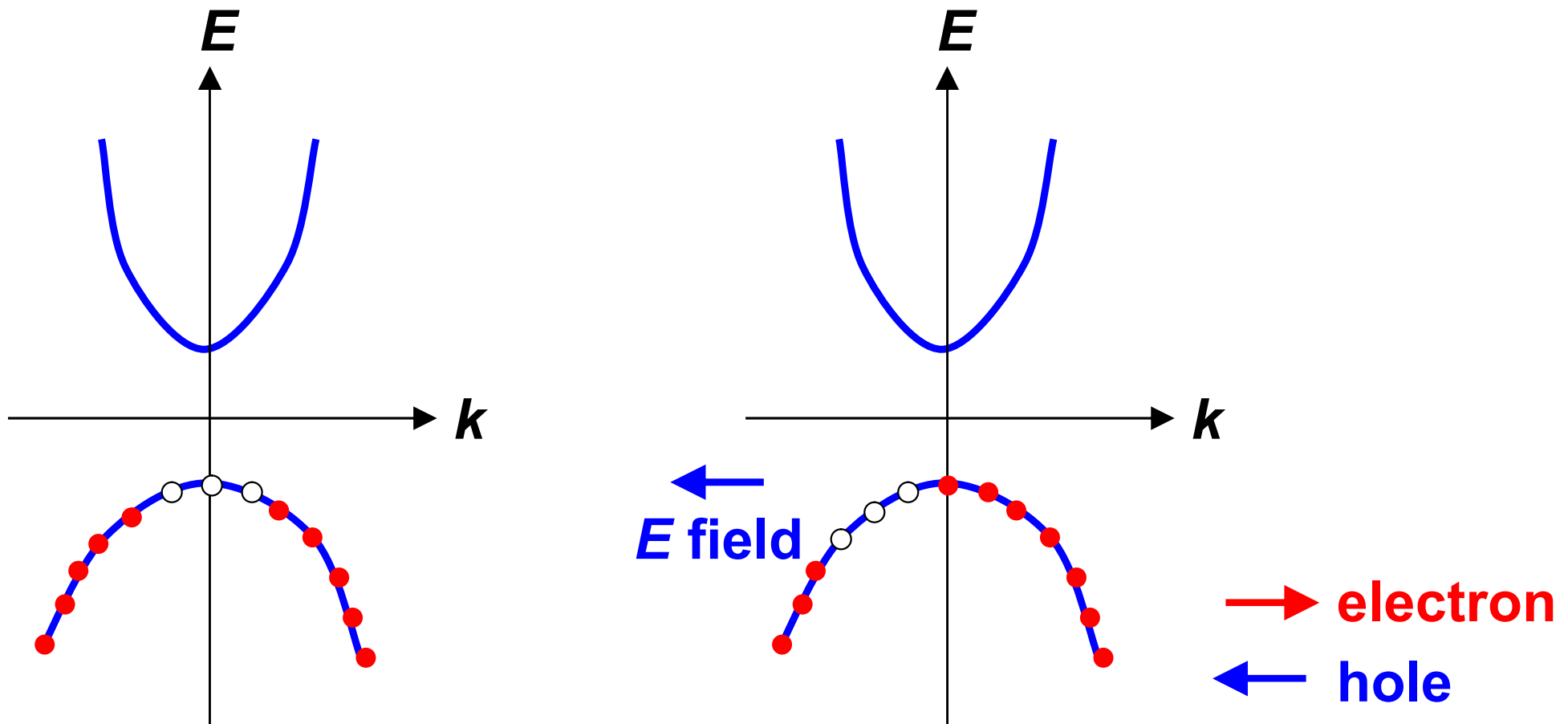
$$m_e^* > 0$$

$$m_e^* < 0$$



Hole 空穴

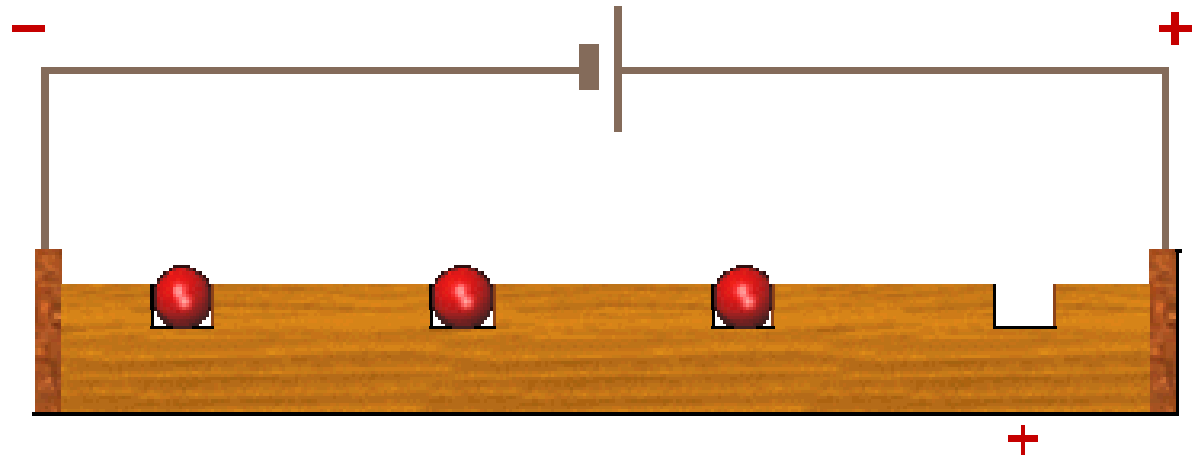
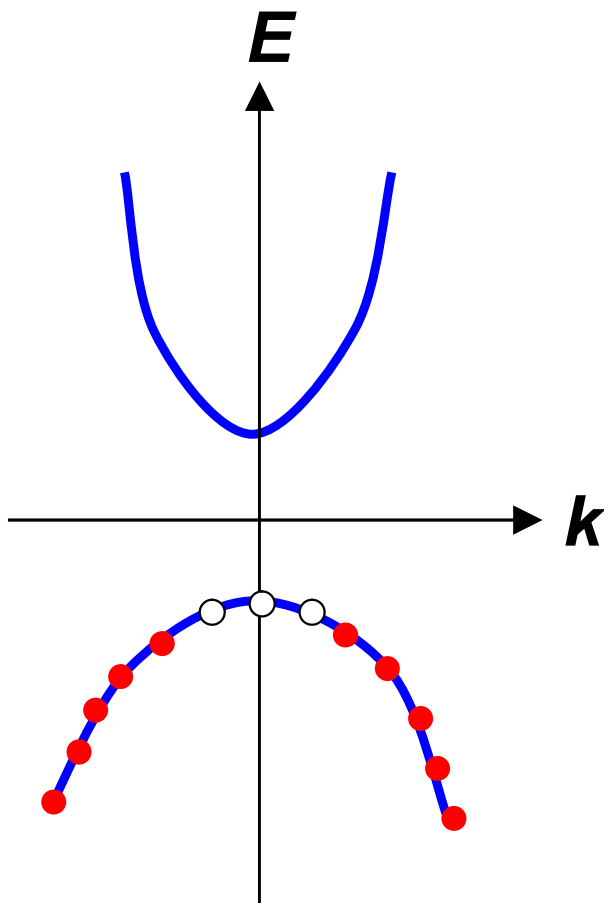
We conventionally use *holes* to analyze the electron behaviors in VB



hole is the absence of an electron

Hole 空穴

We conventionally use *holes* to analyze the electron behaviors in VB

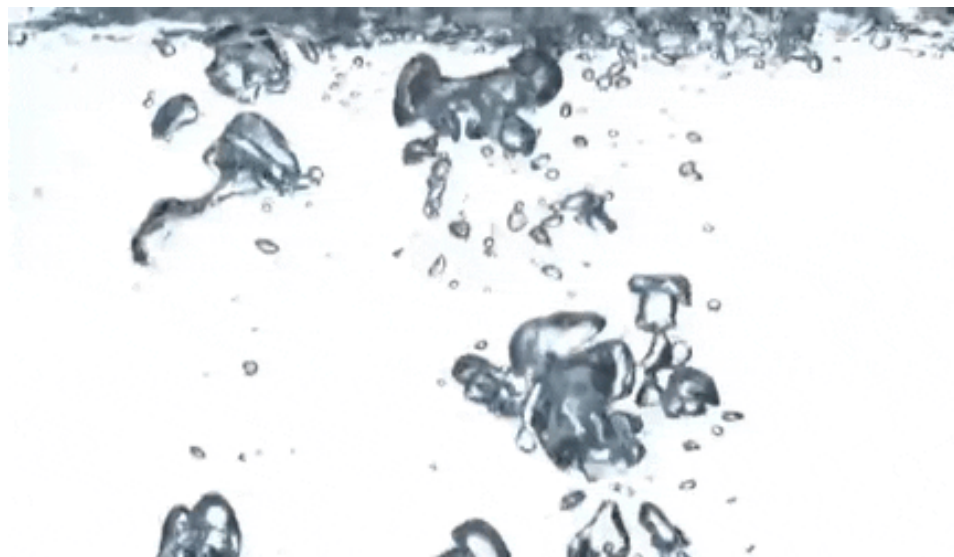
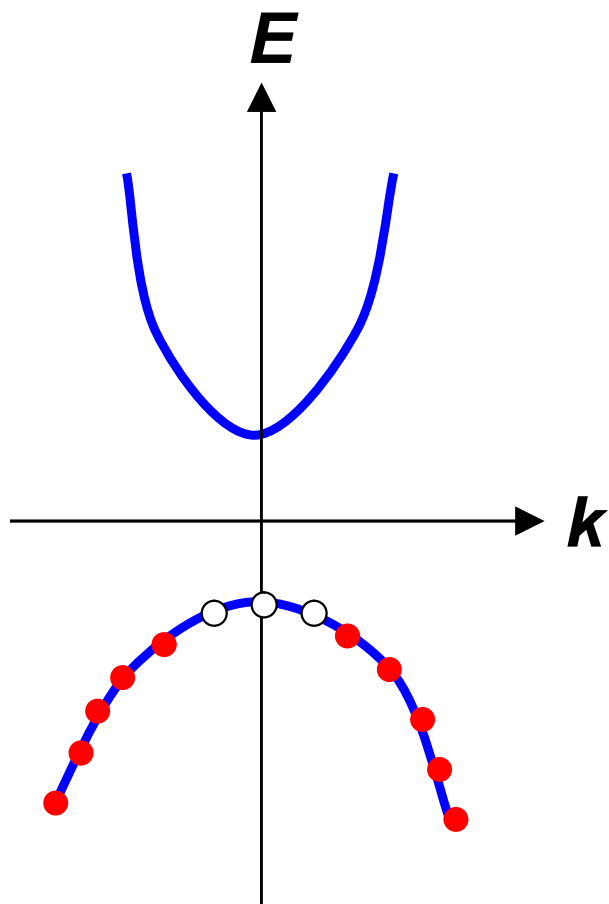


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hole is a quasi-particle (准粒子),
different from positron (正电子)

Hole 空穴

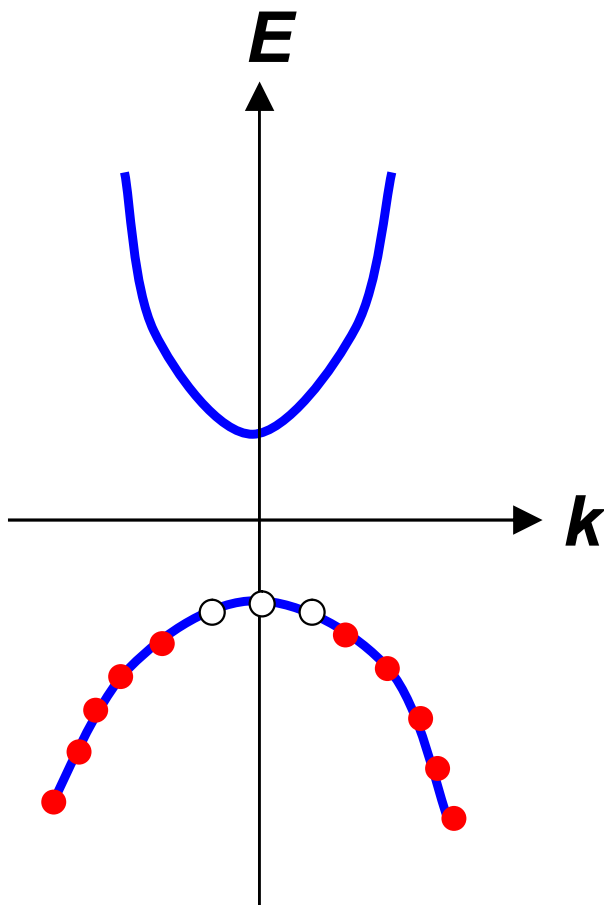
We conventionally use *holes* to analyze the electron behaviors in VB



air bubbles in water

Hole 空穴

In VB, properties of a hole compared to a missing electron in the same position of the band



charge

$$q_h = -e$$

wavevector

$$\mathbf{k}_h = -\mathbf{k}_e$$

energy

$$E_h = -E_e$$

group velocity

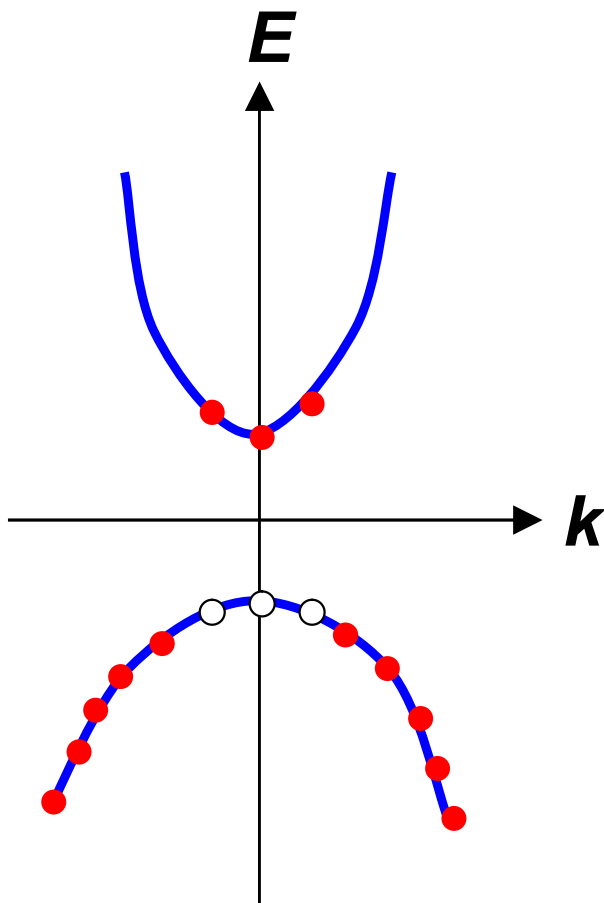
$$\mathbf{v}_h = \mathbf{v}_e$$

effective mass

$$m_h^* = -m_e^*$$

Carriers 载流子

Particles that conduct electrical current:
electrons in CB and holes in VB



in CB

$$m_e^* > 0$$

electron mobility

$$\mu_e = \frac{e^2 \tau}{m_e^*}$$

in VB

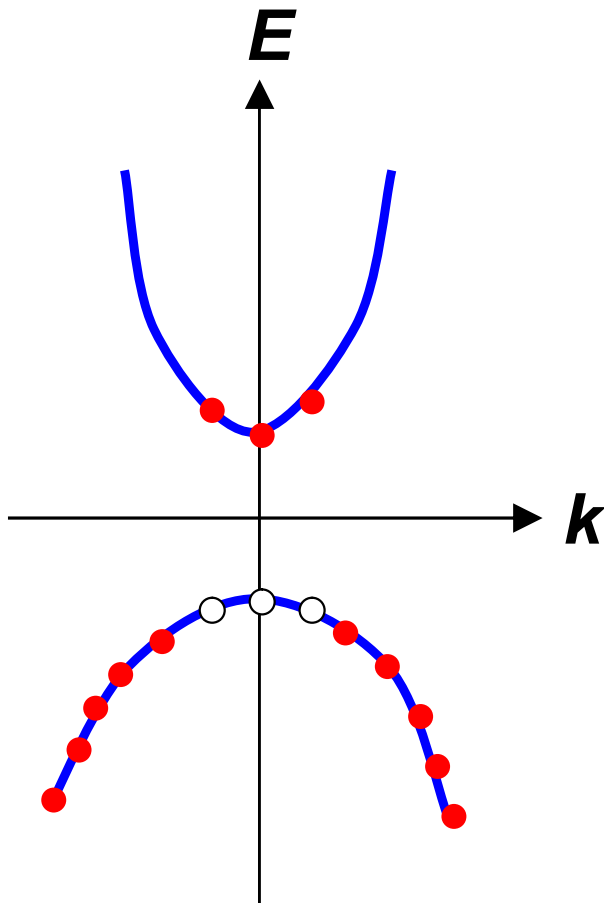
$$m_h^* > 0$$

hole mobility

$$\mu_h = \frac{e^2 \tau}{m_h^*}$$

Carriers 载流子

Particles that conduct electrical current:
electrons in CB and holes in VB



Q: How to calculate:
 m_e^* in CB
 m_h^* in VB?

The Nearly Free Electron Model

$$\begin{vmatrix} \frac{\hbar^2}{2m}(k-g)^2 - E & -V_1 \\ -V_1 & \frac{\hbar^2}{2m}k^2 - E \end{vmatrix} = 0$$

$$\rightarrow \left[\frac{\hbar^2}{2m}(k-g)^2 - E \right] \left[\frac{\hbar^2}{2m}k^2 - E \right] - V_1^2 = 0$$



$$E_1(k), E_2(k)$$

The Nearly Free Electron Model

Nearly Free electron



$$V_1 \neq 0$$

and

$$V_1 \ll \frac{\hbar^2}{2m} \left(\frac{\pi}{a} \right)^2$$

$$\left[\frac{\hbar^2}{2m} (k - g)^2 - E \right] \left[\frac{\hbar^2}{2m} k^2 - E \right] - V_1^2 = 0$$



$$E_{\pm}(k) = \frac{(A + B) \pm \sqrt{(A - B)^2 + 4V_1^2}}{2}$$

$$A = \frac{\hbar^2}{2m} k^2$$

$$B = \frac{\hbar^2}{2m} (k - g)^2$$

The Nearly Free Electron Model

Nearly Free electron



$$V_1 \neq 0$$

and

$$V_1 \ll \frac{\hbar^2}{2m} \left(\frac{\pi}{a} \right)^2$$

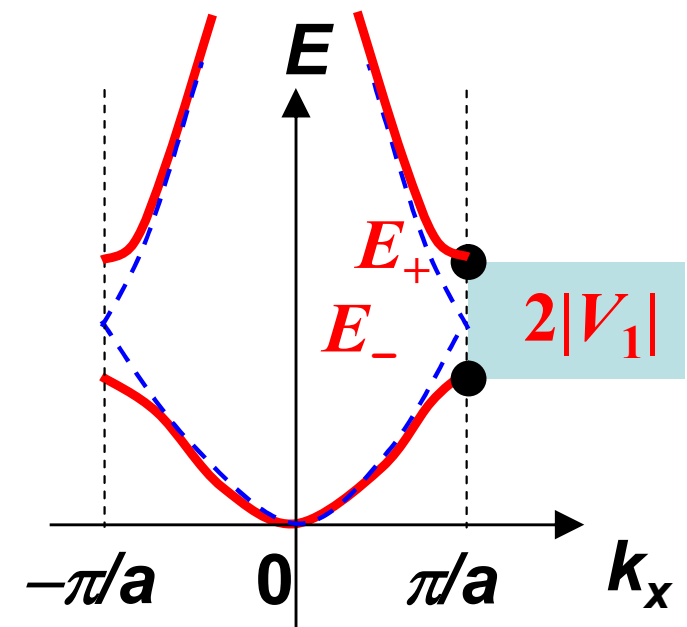
$$\left[\frac{\hbar^2}{2m} (k - g)^2 - E \right] \left[\frac{\hbar^2}{2m} k^2 - E \right] - V_1^2 = 0$$

when $k = \pi/a$

$$E_+ \left(k = \frac{\pi}{a} \right) = \frac{\hbar^2}{2m} \left(\frac{\pi}{a} \right)^2 + |V_1|$$



$$E_- \left(k = \frac{\pi}{a} \right) = \frac{\hbar^2}{2m} \left(\frac{\pi}{a} \right)^2 - |V_1|$$



Band Gap $E_g!$

The Nearly Free Electron Model

Nearly Free electron \longrightarrow $V_1 \neq 0$

$$\left[\frac{\hbar^2}{2m} (k - g)^2 - E \right] \left[\frac{\hbar^2}{2m} k^2 - E \right] - V_1^2 = 0$$

when $k \sim \pi/a$, $(A - B) \sim 0$, take the first order approximation

$$E_{\pm}(k) = \frac{(A + B) \pm \sqrt{(A - B)^2 + 4V_1^2}}{2}$$

$$\longrightarrow E_{\pm}(k) \approx \frac{A + B}{2} \pm V_1 \left[1 + \frac{1}{2} \frac{(A - B)^2}{4V_1^2} \right]$$

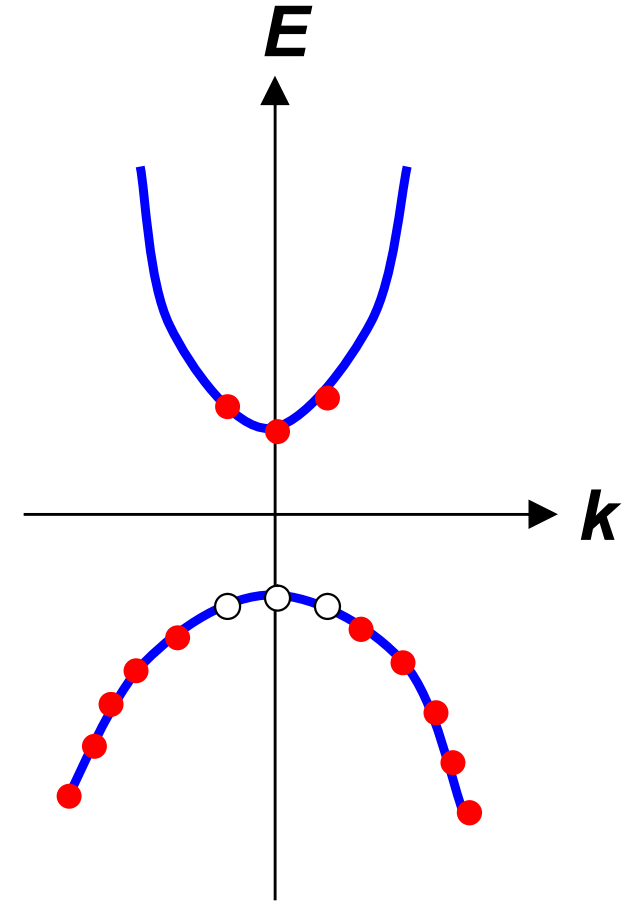
Effective Mass 有效质量

$$E_{\pm}(k) \approx \frac{A+B}{2} \pm V_1 \left[1 + \frac{1}{2} \frac{(A-B)^2}{4V_1^2} \right]$$

$$\frac{1}{m^*} = \frac{1}{\hbar^2} \frac{d^2 E(k)}{dk^2}$$

$$\rightarrow \begin{cases} \frac{m_e^*}{m_0} \approx \frac{1}{C/V_1 + 1} \\ \frac{m_h^*}{m_0} \approx \frac{1}{C/V_1 - 1} \end{cases}$$

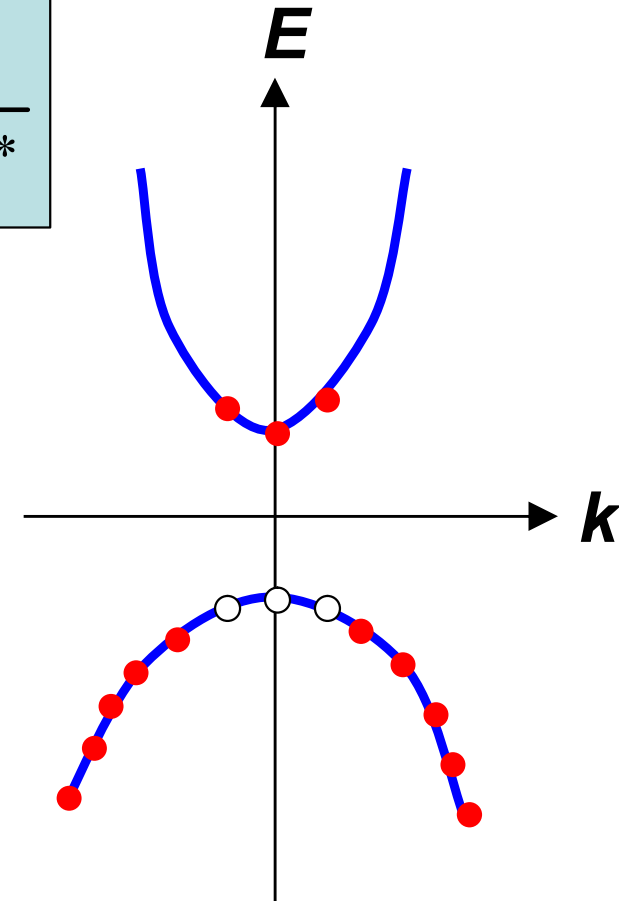
$$C = \frac{\hbar^2 g^2}{4m}$$



Effective Mass 有效质量

$$\left\{ \begin{array}{l} \frac{m_e^*}{m_0} \approx \frac{1}{C/V_1 + 1} \\ \frac{m_h^*}{m_0} \approx \frac{1}{C/V_1 - 1} \end{array} \right.$$

$$\mu = e \frac{\tau}{m^*}$$

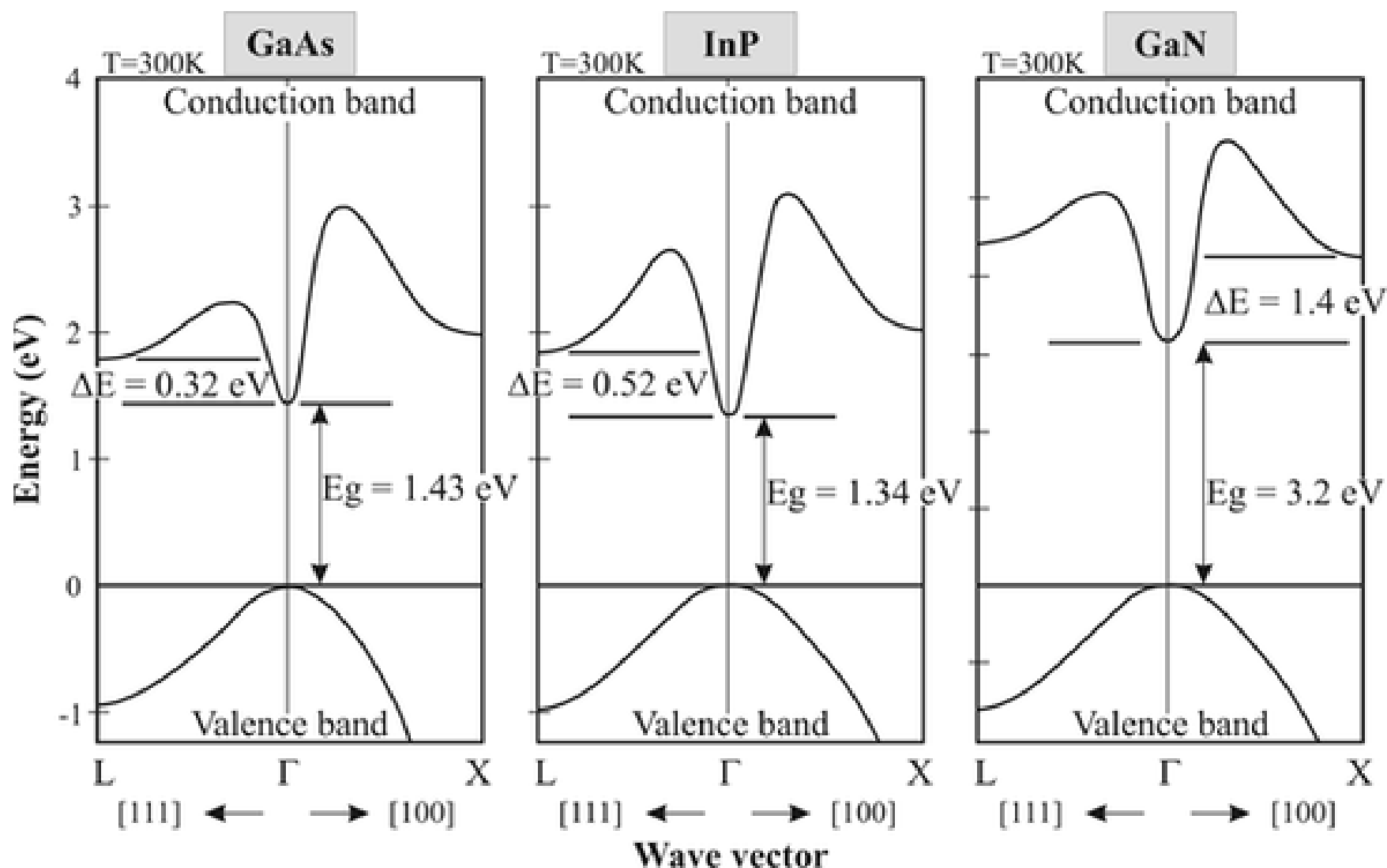


For many semiconductors,
 V_1 is very small ($C/V_1 \sim 1-10$)

$$\rightarrow m_e^* < m_h^* < m_0$$

- Effective mass is smaller than real electron mass m_0
- m_e^* in CB is smaller than m_h^* in VB
- small V_1 ----> small m^* ----> large mobility μ

Examples



**m_e^* in CB is smaller than m_h^* in VB
(electrons have more freedom than holes)**

Examples

	a (Å)	E_g (eV)	m_e^* / m_0	m_h^* / m_0	μ_e (cm ² /V/s)	μ_h (cm ² /V/s)
Si	5.43	1.1	0.26	0.38	1350	450
Ge	5.66	0.66	0.12	0.23	3900	1900
-	-	-	-	-	-	-
GaAs	5.65	1.42	0.067	0.45	8500	400
InAs	6.06	0.35	0.022	0.40	33000	450

* effective mass for conductivity

1. *large atoms* ----> *small V_1* ----> *small E_g*
 ----> *small m^** ----> *large mobility μ*

2. $m_e^* < m_h^* < m_0$

3. $\mu_e^* > \mu_h^*$

Examples

	a (Å)	E_g (eV)	m_e^* / m_0	m_h^* / m_0	μ_e (cm ² /V/s)	μ_h (cm ² /V/s)
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* effective mass for conductivity

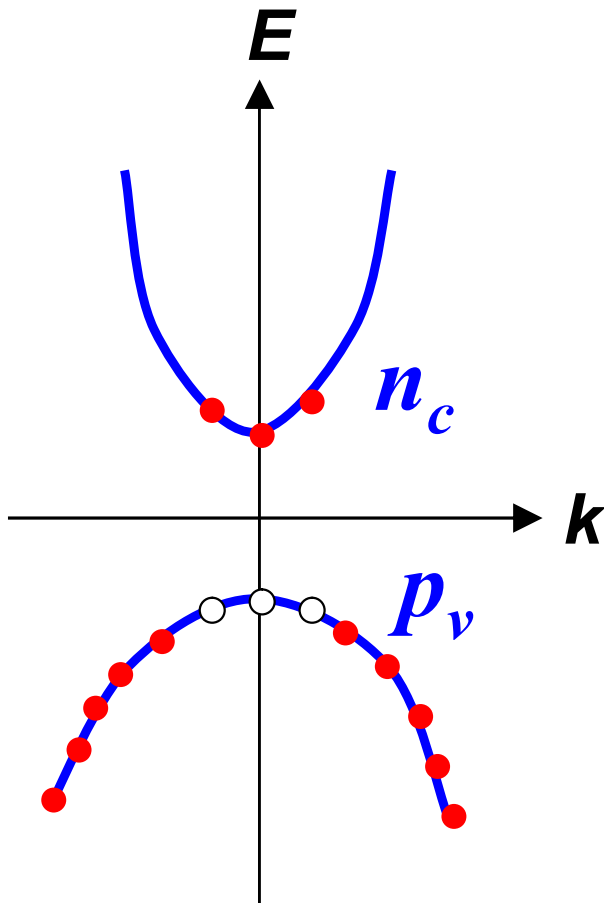
larger atoms

----> electrons have more freedom

----> smaller m^ , move faster*

Carriers 载流子

Particles that conduct electrical current:
electrons in CB and holes in VB



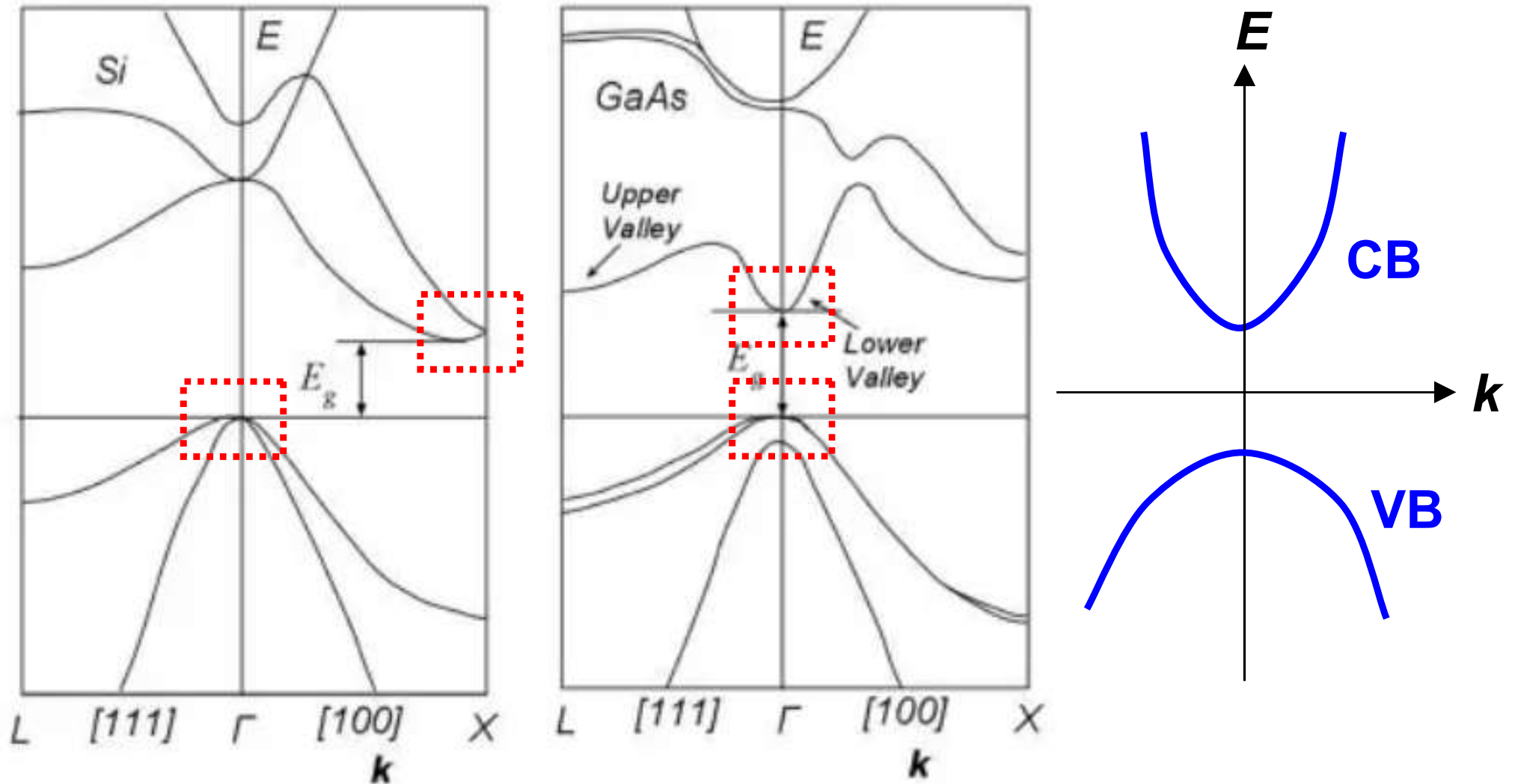
electrical conductivity

$$\sigma = n_c e \mu_e + p_v e \mu_h$$

Q: How to calculate carrier densities?

n_c and p_v (#/cm³)

Band Diagram of Semiconductors



The peaks and valleys of VB and CB can be approximately by *parabolic functions*

Band Diagram of Semiconductors

electrons and holes can be approximated using

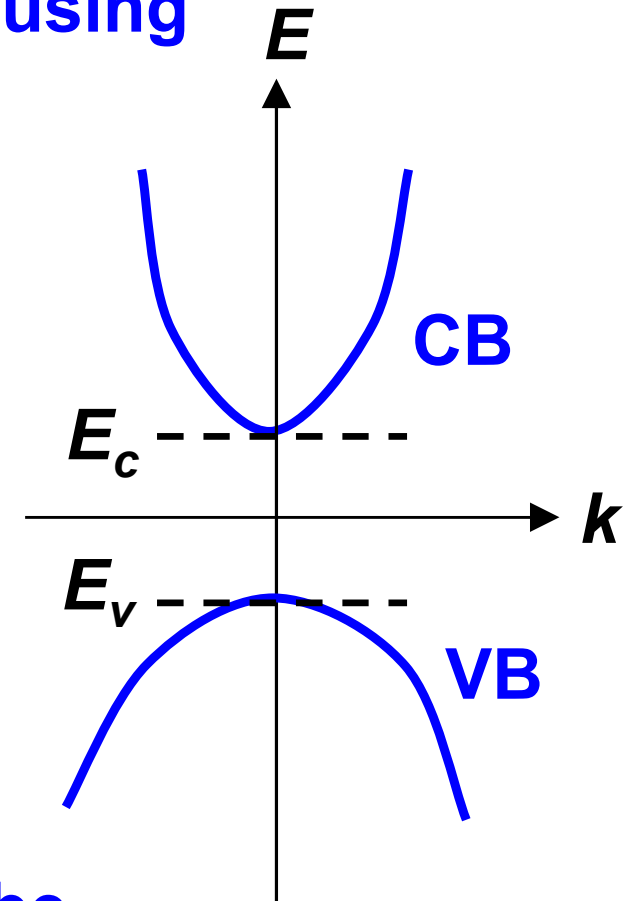
free electron gas

- modify the Sommerfeld Model

$$E_c - E_v = E_g$$

$$E(k) = E_c + \frac{\hbar^2 k^2}{2m_e^*}$$

$$E(k) = E_v - \frac{\hbar^2 k^2}{2m_h^*}$$



The peaks and valleys of VB and CB can be approximated by **parabolic functions**

Q: How many electrons and holes?

Density of States (DOS) 态密度

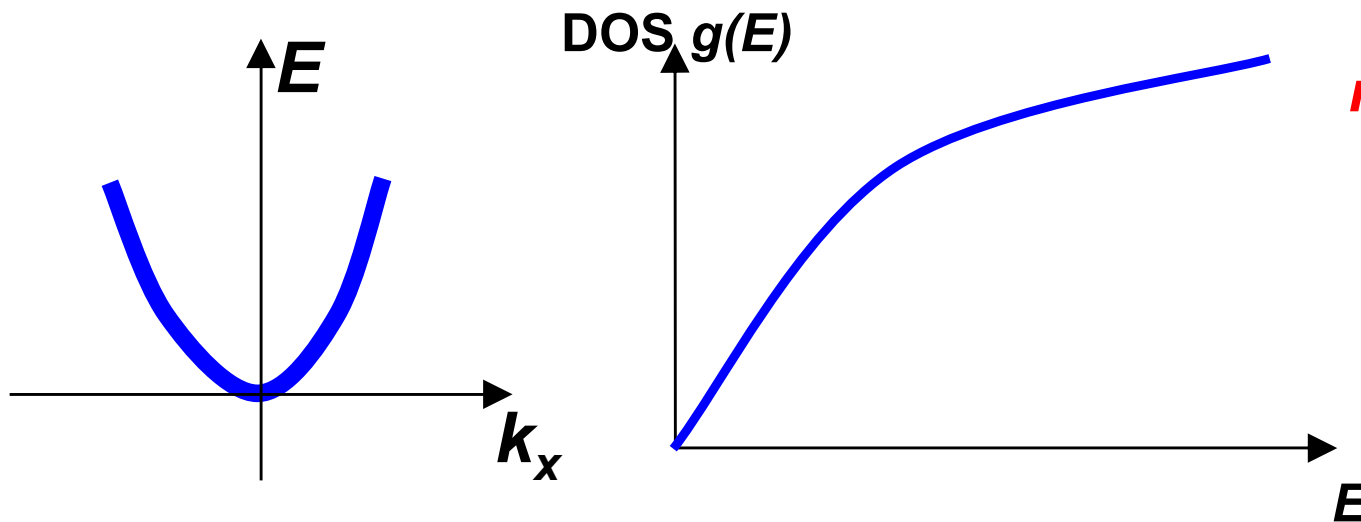
$$g(E) = \frac{dn}{dE}$$

DOS - number of energy states/levels per unit energy in $[E, E+dE]$, per unit volume

free electrons
in 3D

$$E = \frac{\hbar^2 k^2}{2m_e}$$

$$g(E) = \frac{dn}{dE} = \frac{1}{2\pi^2} \left(\frac{2m_e}{\hbar^2} \right)^{3/2} E^{1/2}$$



replace mass m
with effective mass m^*

Density of States (DOS) 态密度

$$g(E) = \frac{dn}{dE}$$

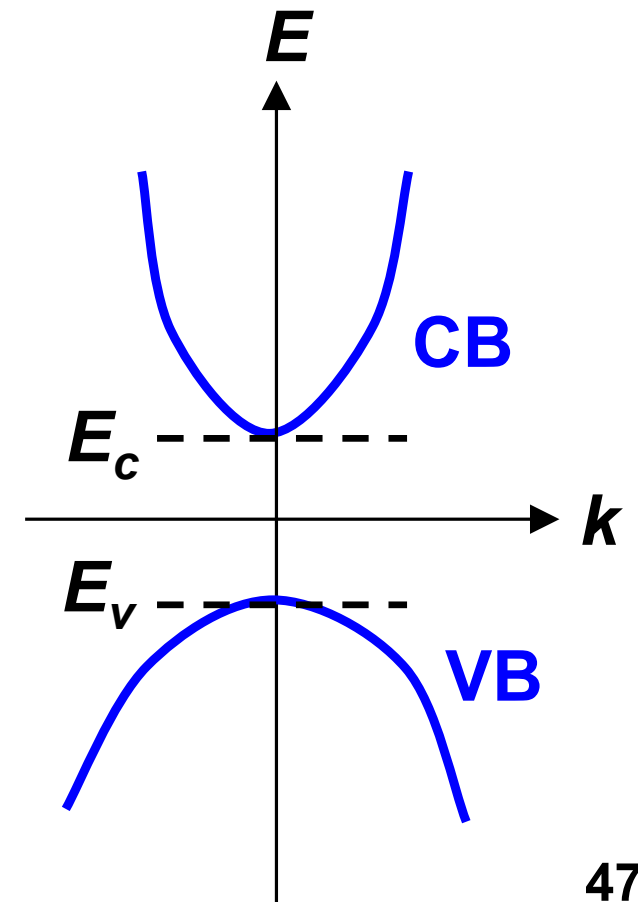
DOS - number of energy states/levels per unit energy in $[E, E+dE]$, per unit volume

DOS for electrons in CB

$$g_c(E) = \frac{1}{2\pi^2} \left(\frac{2m_e^*}{\hbar^2} \right)^{3/2} (E - E_c)^{1/2}$$

DOS for holes in VB

$$g_v(E) = \frac{1}{2\pi^2} \left(\frac{2m_h^*}{\hbar^2} \right)^{3/2} (E_v - E)^{1/2}$$



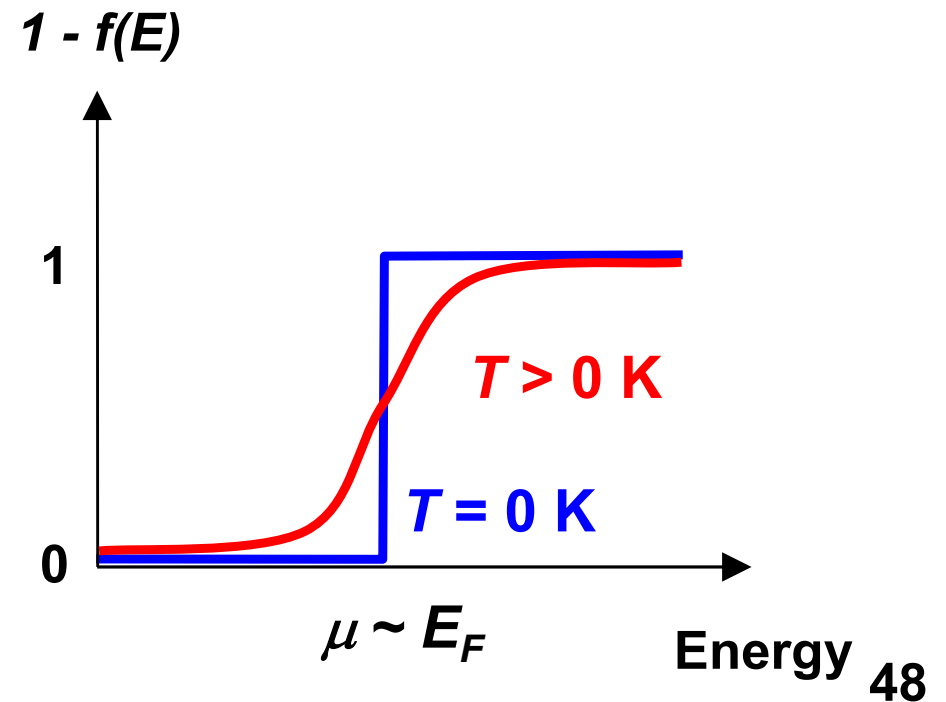
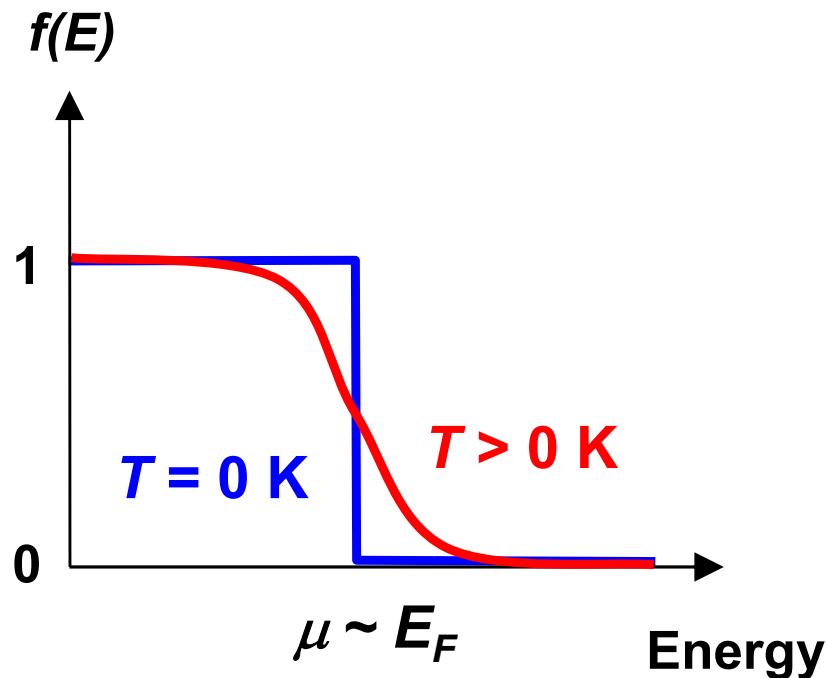
Density of Carriers

**Density of electrons
= DOS * probability f**

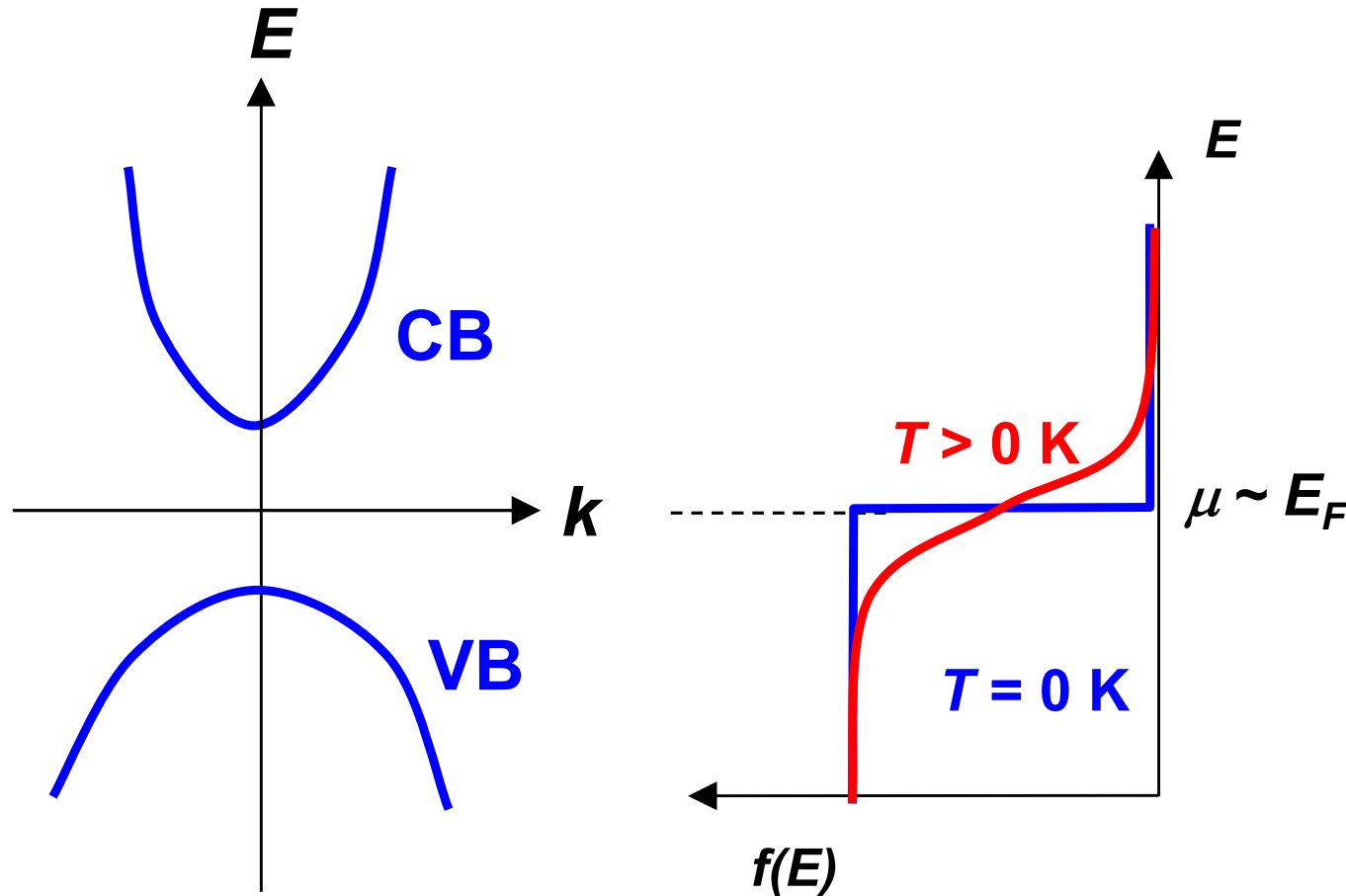
**Density of holes =
DOS * $(1-f)$**

$$f(E) = \frac{1}{e^{(E-\mu)/k_B T} + 1}$$

$$1 - f(E) = 1 - \frac{1}{e^{(E-\mu)/k_B T} + 1} = \frac{1}{e^{(\mu-E)/k_B T} + 1}$$



Chemical Potential



For pure semiconductors (intrinsic), the chemical potential μ (Fermi level E_F) lie within the band gap.

Fermi Energy E_F - A Little Note

In metals, Fermi energy/level E_F is the highest occupied state of electrons at $T = 0$ K.

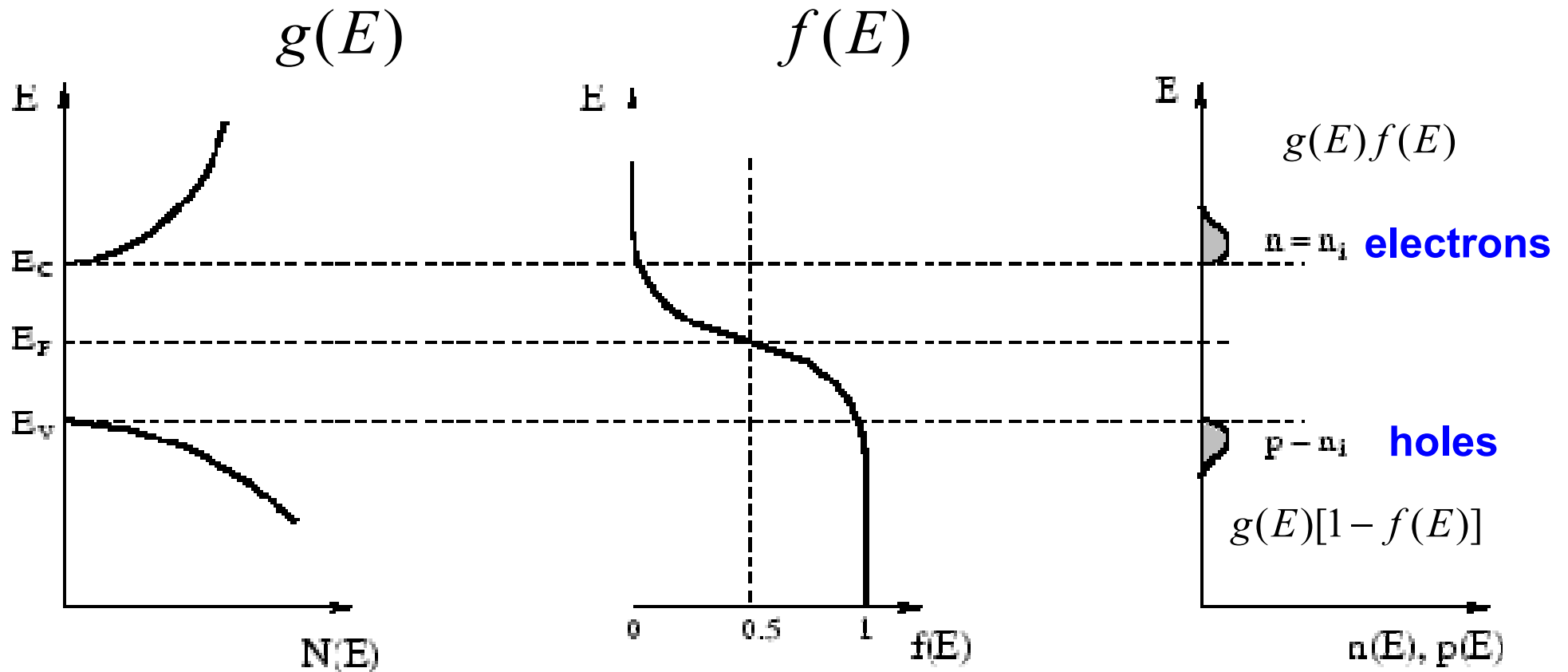
In semiconductors, Fermi energy/level E_F is referred to the chemical potential μ , which is inside the gap. No electrons at E_F !

"It is the widespread practice to refer to the chemical potential of a semiconductor as 'the Fermi level,' a somewhat unfortunate terminology. ... The term 'Fermi level' should be regarded as nothing more than a synonym for 'chemical potential,' in the context of semiconductors."

---- Ashcroft & Mermin, p573

Density of Carriers = DOS * Probability

Intrinsic



DOS

**electron
probability**

carriers

Density of Carriers

electrons in CB

$$n_c = \int_{E_c}^{+\infty} g_c(E) \cdot f(E) dE$$

If μ is in the gap, assume

$$E_c - \mu \gg k_B T$$



$$f(E) = \frac{1}{e^{(E-\mu)/k_B T} + 1}$$

$$\approx e^{-(E-\mu)/k_B T}$$

holes in VB

$$p_v = \int_{-\infty}^{E_v} g_v(E) \cdot [1 - f(E)] dE$$

$$\mu - E_v \gg k_B T$$



$$1 - f(E) = \frac{1}{e^{(\mu-E)/k_B T} + 1}$$

$$\approx e^{-(\mu-E)/k_B T}$$

Non-Degenerate semiconductors (非简并半导体):
Fermi-Dirac is approximated by Maxwell-Boltzmann distribution
not valid for high temperature or small band gap

Density of Carriers

electrons in CB

$$\begin{aligned}
 n_c &= \int_{E_c}^{+\infty} g_c(E) \cdot f(E) dE \\
 &= \int_{E_c}^{+\infty} \frac{1}{2\pi^2} \left(\frac{2m_e^*}{\hbar^2} \right)^{3/2} (E - E_c)^{1/2} \cdot e^{-(E-\mu)/k_B T} dE \\
 &= \frac{1}{4} \left(\frac{2m_e^* k_B T}{\pi \hbar^2} \right)^{3/2} e^{-(E_c - \mu)/k_B T} \\
 &= N_c(T) e^{-(E_c - \mu)/k_B T}
 \end{aligned}$$

$$N_c(T) = \frac{1}{4} \left(\frac{2m_e^* k_B T}{\pi \hbar^2} \right)^{3/2} = 2.5 \left(\frac{m_e^*}{m_0} \right)^{3/2} \left(\frac{T}{300 \text{ K}} \right)^{3/2} \times 10^{19} \text{ cm}^{-3}$$

Density of Carriers

note here we use the integral

$$\int_0^{+\infty} x^{1/2} \cdot e^{-x/a} dx = \frac{\sqrt{\pi}}{2} a^{3/2}$$

so

$$\begin{aligned} & \int_{E_c}^{+\infty} (E - E_c)^{1/2} \cdot e^{-(E-\mu)/k_B T} dE \\ &= \frac{\sqrt{\pi}}{2} (k_B T)^{3/2} e^{-(E_c - \mu)/k_B T} \end{aligned}$$

Density of Carriers

holes in VB

$$\begin{aligned}
 p_v &= \int_{-\infty}^{E_v} g_v(E) \cdot [1 - f(E)] dE \\
 &= \int_{-\infty}^{E_v} \frac{1}{2\pi^2} \left(\frac{2m_h^*}{\hbar^2} \right)^{3/2} (E_v - E)^{1/2} \cdot e^{-(\mu - E)/k_B T} dE \\
 &= \frac{1}{4} \left(\frac{2m_h^* k_B T}{\pi \hbar^2} \right)^{3/2} e^{-(\mu - E_v)/k_B T} \\
 &= P_v(T) e^{-(\mu - E_v)/k_B T}
 \end{aligned}$$

$$P_v(T) = \frac{1}{4} \left(\frac{2m_h^* k_B T}{\pi \hbar^2} \right)^{3/2} = 2.5 \left(\frac{m_h^*}{m_0} \right)^{3/2} \left(\frac{T}{300 \text{ K}} \right)^{3/2} \times 10^{19} \text{ cm}^{-3}$$

Density of Carriers

$$N_c(T) = \frac{1}{4} \left(\frac{2m_e^* k_B T}{\pi \hbar^2} \right)^{3/2} = 2.5 \left(\frac{m_e^*}{m_0} \right)^{3/2} \left(\frac{T}{300 \text{ K}} \right)^{3/2} \times 10^{19} \text{ cm}^{-3}$$

$$P_v(T) = \frac{1}{4} \left(\frac{2m_h^* k_B T}{\pi \hbar^2} \right)^{3/2} = 2.5 \left(\frac{m_h^*}{m_0} \right)^{3/2} \left(\frac{T}{300 \text{ K}} \right)^{3/2} \times 10^{19} \text{ cm}^{-3}$$

effective density of states (有效态密度)

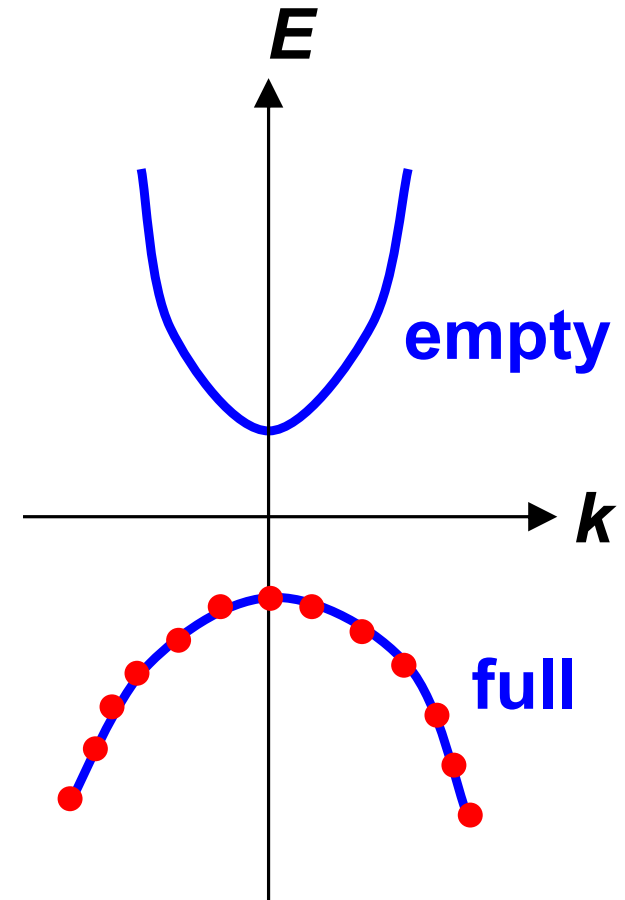
no physical meaning, just two constants

Density of Carriers

when $T = 0$ K

$$n_c = N_c(T) e^{-(E_c - \mu)/k_B T} = 0$$

$$p_v = P_v(T) e^{-(\mu - E_v)/k_B T} = 0$$



$T = 0$ K
insulator

Density of Carriers

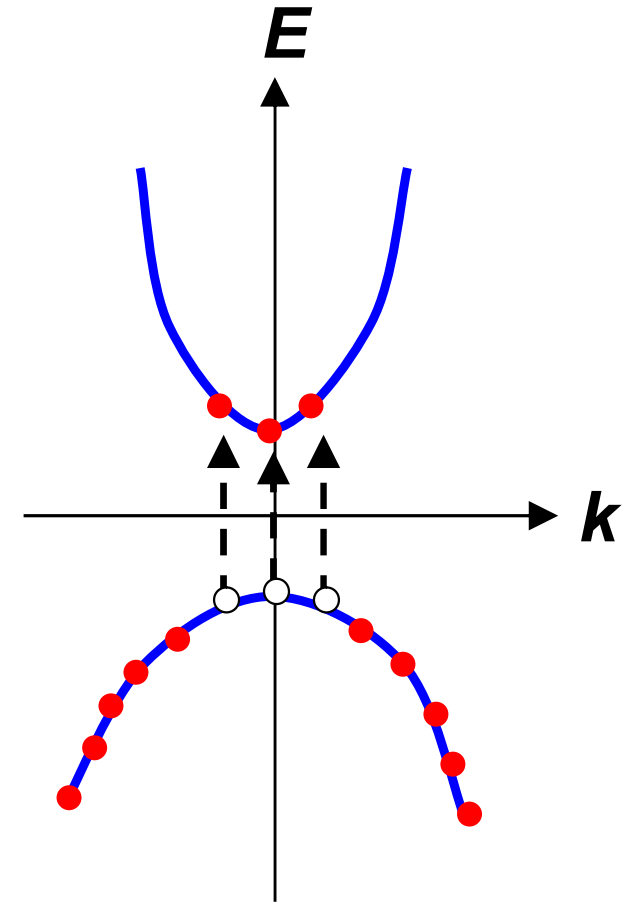
when $T > 0$ K

$$n_c = N_c(T) e^{-(E_c - \mu)/k_B T} > 0$$

$$p_v = P_v(T) e^{-(\mu - E_v)/k_B T} > 0$$

conductivity

$$\sigma = n_c e \mu_e + p_v e \mu_h$$



$T > 0$ K

thermalization 热激发
CB and VB are partly filled
conductor

Density of Carriers

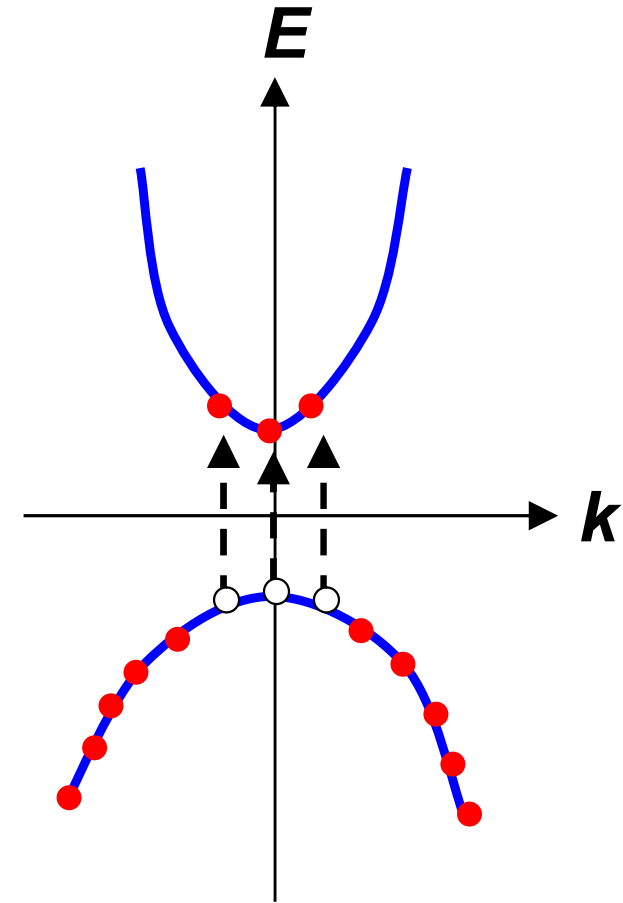
when $T > 0$ K

$$n_c = N_c(T) e^{-(E_c - \mu)/k_B T} > 0$$

$$p_v = P_v(T) e^{-(\mu - E_v)/k_B T} > 0$$



$$\begin{aligned} n_c p_v &= N_c(T) P_v(T) e^{-(E_c - E_v)/k_B T} \\ &= N_c(T) P_v(T) e^{-E_g/k_B T} \end{aligned}$$



mass action law

at equilibrium, $n_c p_v$ is a constant

Carriers in Semiconductors

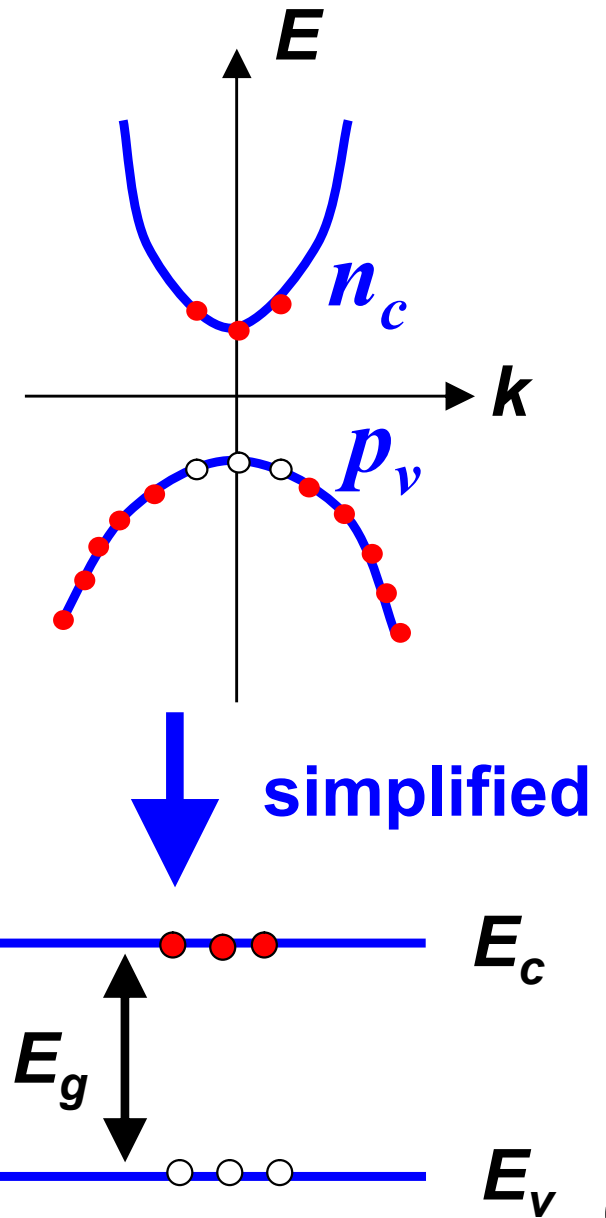
- For calculations here, we go back to classical physics, assume:

- Carriers are much fewer than DOS

$$f(E) \ll 1$$

- Carriers are non-Degenerate (Boltzmann Distribution)
- Carriers are almost in the same energies (E_c and E_v)
- Carriers have the same velocities and motilities

$$\sigma = n_c e \mu_e + p_v e \mu_h$$



Mass Action Law - A Little Notion

- The product of electron and hole concentrations is a constant, at a fixed temperature

$$n_c p_v = n_i^2 = N_v(T) P_v(T) e^{-E_g/k_B T}$$

- In water, the product of H⁺ and OH⁻ concentrations is also a constant

$$[\text{H}^+][\text{OH}^-] = K_w = 10^{-14} (\text{mol/L})^2 \quad (\text{at } 25 \text{ }^\circ\text{C})$$

- Both are originated from classical statistics (non-degenerate, Maxwell-Boltzmann distribution), *not* related to quantum mechanics

Thank you for your attention